

PROCESS TOMOGRAPHY

by

MAIZATUL NIZA BINTI ZAINAL

FINAL PROJECT REPORT

Submitted to the Electrical & Electronics Engineering Programme

in Partial Fulfillment of the Requirements

for the Degree

Bachelor of Engineering (Hons)

Electrical & Electronics Engineering

Universiti Teknologi PETRONAS

Bandar Seri Iskandar

31750 Tronoh

Perak Darul Ridzuan

© Copyright 2006

by

Maizatul Niza binti Zainal, 2006

CERTIFICATION OF APPROVAL

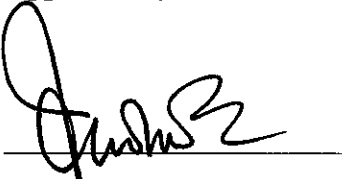
PROCESS TOMOGRAPHY

by

Maizatul Niza binti Zainal

A project dissertation submitted to the
Electrical & Electronics Engineering Programme
Universiti Teknologi PETRONAS
in partial fulfillment of the requirement for the
BACHELOR OF ENGINEERING (Hons)
(ELECTRICAL & ELECTRONICS ENGINEERING)

Approved by,



Associate Professor Dr. Mohd Noh Karsiti

Project Supervisor

UNIVERSITI TEKNOLOGI PETRONAS

TRONOH, PERAK

June 2006

CERTIFICATION OF ORIGINALITY

This is to certify that I am responsible for the work submitted in this project, that the original work is my own except as specified in the references and acknowledgements, and that the original work contained herein have not been undertaken or done by unspecified sources or persons.



Maizatul Niza binti Zainal

ABSTRACT

Process tomography is a process of measuring the signals by using specific types of sensor, which are arranged around an object as to examine its internal condition. A number of principles can be applied in process tomography including optical tomography, resistive tomography, and acoustic tomography. This report describes the design of hardware system for electrical capacitance tomography. The electrical capacitance tomography is defined by measuring the electrical properties of dielectric components in a specific object via capacitive sensors. In this project, the hardware system is designed based on two major parts; sensor system and data acquisition system. A number of experiments have been conducted in order to obtain the best design of the sensor system and data acquisition circuits. Further improvements are suggested for future works.

ACKNOWLEDGEMENT

I would like to express my gratitude to the Almighty for giving me the strength and courage in completing the project entitled 'Process Tomography'.

Here, I dedicate my utmost appreciation to my project supervisor Associate Professor Dr. Mohd Noh Karsiti, who has guided me during the completion of this project and patiently examine my work into the details in order to produce an outstanding project and paperwork.

Then, special thanks to Dr. Pham for his suggestions to improve the performance of this project.

This gratitude also goes to all Electrical and Electronics Engineering Laboratory technicians for their assistance in laboratory works especially Miss Siti Hawa.

Last but not least, thank you to my family and colleagues who have been very supportive in giving me the ongoing spirits from the beginning of the project. Not to forget to all other people who are not mentioned here.

Thank you.

TABLE OF CONTENTS

CERTIFICATION OF APPROVAL.....	ii
CERTIFICATION OF ORIGINALITY.....	iii
ABSTRACT.....	iv
ACKNOWLEDGEMENT.....	v
LIST OF TABLES.....	ix
LIST OF FIGURES.....	x
LIST OF ABBREVIATION.....	xi
CHAPTER 1: INTRODUCTION.....	1
1.1 BACKGROUND OF STUDY.....	1
1.2 PROBLEM STATEMENT.....	4
1.3 OBJECTIVES AND SCOPE OF STUDY.....	4
CHAPTER 2: LITERATURE REVIEW AND THEORY.....	5
2.1 OVERALL DESIGN OF THE SYSTEM.....	5
2.2 CAPACITIVE SENSOR.....	5
2.2.1 <i>Principle</i>	7
2.2.2 <i>Dielectric constant</i>	8
2.2.3 <i>Sensor characteristics</i>	8
2.3 DATA ACQUISITION SYSTEM.....	10
2.3.1 <i>Amplifiers</i>	11
2.3.2 <i>Charge amplifier circuit</i>	12
2.3.3 <i>Analog to digital converter</i>	14
2.4 IMAGE RECONSTRUCTION SYSTEM.....	15

CHAPTER 3: METHODOLOGY.....	16
3.1 LITERATURE REVIEW AND RESEARCH.....	16
3.2 CIRCUIT DESIGN.....	16
3.3 EXPERIMENTAL.....	18
3.4 ANALYSIS.....	18
3.5 COMPUTER-DEVICE COMMUNICATION DEVELOPMENT.....	18
3.6 COMISSIONING AND VERIFICATION.....	19
 CHAPTER 4: PROJECT WORK.....	 20
4.1 HARDWARE.....	20
4.1.1 <i>Sensor system</i>	20
4.1.2 <i>Capacitance measurement circuit</i>	22
4.1.3 <i>Multiplexer</i>	25
4.1.4 <i>Instrumentation amplifier and differential amplifier</i>	25
4.1.5 <i>Offset and gain control units</i>	26
4.1.6 <i>Analog to digital converter</i>	27
4.1.7 <i>Control logic circuit</i>	28
4.1.8 <i>Communication circuit between hardware and computer</i>	30
4.2 SOFTWARE.....	31
4.2.1 <i>Image reconstruction programming</i>	31
 CHAPTER 5: RESULT AND DISCUSSION.....	 33
 CHAPTER 6: CONCLUSION AND RECOMMENDATION.....	 42
6.1 CONCLUSION.....	42
6.2 RECOMMENDATION.....	43
 REFERENCES.....	 44

APPENDICES	45
APPENDIX A Dielectric material and dielectric constant	
APPENDIX B Gantt chart of two semesters final year project	
APPENDIX C Truth table and K map for control logic circuit design	
APPENDIX D CMOS switches CD4066B Data sheet	
APPENDIX E Operational amplifier LF353 Data sheet	
APPENDIX F Multiplexer CD4051 Data sheet	
APPENDIX G PIC16F877 (ADC Conversion)	
APPENDIX H MAX 232 Data sheet	

LIST OF TABLES

Table 1.1	Examples of process tomography techniques in process industries.....	2
Table 1.2	Sensors for process tomography.....	3
Table 2.1	Characteristics for the examples of stray-immune measurement circuit.....	11
Table 4.1	J-K flip-flop Excitation Table.....	29
Table 5.1	Values for each component during experimental.....	34
Table 5.2	Results of output voltage (mV) for $C_f = 0.1\text{ nF}$, and $f_s = 1\text{ MHz}$	36

LIST OF FIGURES

Figure 2.1	Electrical capacitance tomography system.....	5
Figure 2.2	Electric charge and voltage define capacitance of a parallel-plate capacitor.....	7
Figure 2.3	Cross-sectional structure of the imaging sensor.....	9
Figure 2.4	Data acquisition system.....	10
Figure 2.5	Charge amplifier circuit as charge-to-voltage converter.....	12
Figure 2.6	Microcontroller 16F877.....	14
Figure 4.1	Sensor system with 4 electrodes: (a) opposite view, (b) top view	21
Figure 4.2	Sensor system with 8 electrodes: (a) opposite view, (b) top view	22
Figure 4.3	Capacitance measurement circuit.....	23
Figure 4.4	Compensation network: eliminate the offset voltage	24
Figure 4.5	Multiplexer connected to the instrument and differential amplifier	25
Figure 4.6	Differential amplifier with buffer amplifiers.....	26
Figure 4.7	Calibration procedure.....	27
Figure 4.8	State transition diagram.....	29
Figure 4.9	The connection between RS232 serial ports with MAX232.....	30
Figure 5.1	Test circuit for capacitance measurement.....	33
Figure 5.2	The linear response of output voltage vs known capacitor, C_x	35
Figure 5.3	Positive linear response for output voltage vs known capacitor, C_x	36
Figure 5.4	Capacitance measurement circuit on the PCB.....	37
Figure 5.5	Comparison of output voltages from circuit on the breadboard and PCB..	38
Figure 5.6	Output voltage for 8 electrodes capacitive sensor system.....	39
Figure 5.7	Hardware system of ECT.....	41

LIST OF ABBREVIATIONS

2-D	Two dimensional
3-D	Three dimensional
A_{OL}	Open loop gain
ADC	Analog to digital converter
ADRESH	Analog digital results HIGH
ADRESL	Analog digital results LOW
BOR	Brown-Out-Reset
C	Capacitance
C_c	Cable capacitance
C_f	Feedback capacitance
C_{inp}	Amplifier input capacitance
C_x	Unknown capacitor
CA	Charge amplifier
CCP	Command Control Processor
ECT	Electrical Capacitance Tomography
FEM	Finite Element Method
GND	Ground
LBP	Linear Back Projection algorithm
LFP	Linear Forward Projection algorithm
Op-amp	Operational amplifier
PWM	Pulse Width Modulation
SNR	Signal to noise ratio
UART	Universal Asynchronous Receiver/Transmitter

CHAPTER 1

INTRODUCTION

1.1 BACKGROUND

Process tomography is a process of measuring the signals by using specific types of sensor. The sensors are arranged around an object, such as pipeline, to examine the internal condition of the subject. The information on the nature of the subject is obtained by reconstructing the measurements from the sensors into a 2-D or 3-D image. The instrument components for process tomography consist of the hardware and software parts. The hardware part consists of the sensor for the signal and the data control of the process tomography. Meanwhile, the software part includes the program for reconstructs the signals and displays the results. Process tomography is already well known in oil and gas industry, as this technology brings a lot of benefits for the engineers to observe and examine the internal condition of process line or equipment.

The applications for process tomography in industrial sectors have been practically used especially in chemical, oil, pharmaceutical, food, biological, minerals, nuclear, environmental, water, healthcare, and materials processing industries. These applications can be categorized into five groups ^[1], which are:

- modeling in laboratory environment.
- process monitoring and control in an industrial environment.
- equipment design and optimization in a laboratory or industrial environment.
- characterization of individual components or products.
- remote sensing in manufacturing, quality control, environmental protection, or pollution control, on an industrial /waste disposal site.

In Table 1.1, the information represents some examples of process tomography methods which are applied in the industry field ^[1].

Table 1.1 Examples of process tomography techniques in process industries

Process application	Process tomography method
Microstructural characterization of components, particles, pastes, foams, filters (1-10 000 μm)*	Magnetic resonance imaging. Neutron tomography. X-ray microtomography. Optical tomography.
Liquid mixing and multiphase flow (0.01-0.5 m)*	Optical tomography. Resistive tomography. Capacitance tomography. Acoustic tomography.
Powder mixing, transport, and conveying (0.01 – 0.5 m)*	Capacitance tomography. Electrodynamics tomography.
Groundwater monitoring and soil remediation (0.01 – 0.5 m)*	Impedance tomography.
Atmospheric pollution monitoring (50 m – 10 km)*	Laser absorption imaging.
Oilfield reservoir exploration (50 m – 50 km)*	Acoustic velocity imaging. Acoustic diffraction tomography.

* typical operating length scales

There are various types of sensor system available that can be implemented in the process tomography. Normally, the sensor systems are based on measurements of electrical characteristics by using the radiation, acoustic, or electrical sensor. For example, the capacitive, conductivity, or inductive types of sensors are used to measure the electrical properties of a target subject in either small or large object in plant such as vessel. These sensors are suitable to apply in electrical properties measurement based on the fast responses from the sensors compare to the others. The applications for the

other types of sensor are summarized in Table 1.2 ^[1].

Table 1.2 Sensors for process tomography

Principle	Practical realization	Comments
Electromagnetic radiation	Optical	Fast, optical access required
	X-ray and γ -ray	Slow, radiation containment
	Positron emission	Labeled particle, not on-line
	Magnetic resonance	Fast, expensive for large vessel
Acoustic	Ultrasonic	Sonic speed limitation, complex to use

Electrical capacitance tomography (ECT) is one of the industrial process tomography systems, which measures the electrical properties of dielectric components in a specific object by using the capacitive sensors. The capacitive sensors provide fast responses for the measurement of permittivity distribution of the mixture in the specific object ^[1]. The sensors consist of a few sets of electrode plates, which are arranged around the specific object. The capacitances between the combination pairs of the electrodes are measured by the capacitance measurement circuit. Then, the measurements are obtained by the sensor electronics and sent to the image-reconstruction computer. The computer generates the tomography images of the permittivity distribution from the measurements by the sensors. The ECT system requires good sensors and sensor electronics design in order to provide low noise level, high stability, and accurate measurement sensitivity distributions during developing 2-D or 3-D images.

1.2 PROBLEM STATEMENT

Process tomography is a system of measuring the signals from a specific object and displaying the signals into an image. The tomography system which applies the electrical capacitance principle will be developed as to provide a platform in exploring the potential application of process tomography in oil and gas industry. In ECT system, it consists of two major parts, which are the hardware and software. The capacitive sensor, measurement circuit, and data acquisition circuit represent the hardware of ECT. Meanwhile, the software system of ECT is the image reconstruction system; the system for imaging the permittivity distribution in the target object. Various principles of electronics circuit, sensor, and image reconstruction are required to accomplish this project.

1.3 OBJECTIVES AND SCOPE OF STUDY

For this project, it is expected to meet the following objectives which are:

- to design a functional hardware system of ECT; including the capacitance sensor, measurement circuit, and data acquisition system.
- to gain the information of potential image reconstruction system which are suitable applied in ECT.

Therefore, this system is required to be developed by following the criteria of ECT for application in oil and gas industry. As a result, these scopes are required to understand deeply on ECT system:

- electrical capacitance principle as to develop the sensor and measurement circuit of ECT .
- electronics theory and circuit design for control and data acquisition system.
- image reconstruction system, in order to display the cross-section of the target object.

A Gantt chart for a guide in completing the project is attached in Appendix B.

CHAPTER 2

LITERATURE REVIEW AND THEORY

2.1 OVERALL DESIGN OF THE SYSTEM

An ECT system can be divided into three main parts; the capacitive sensor, the data acquisition system, and the image reconstruction system. The sensor is the most critical part which involves the quality of the information obtains from the process. This information must be accurate in order to have the best result for the image reconstruction of the internal condition around the sensors. In Figure 2.1, the overall design of the system is illustrated ^[5].

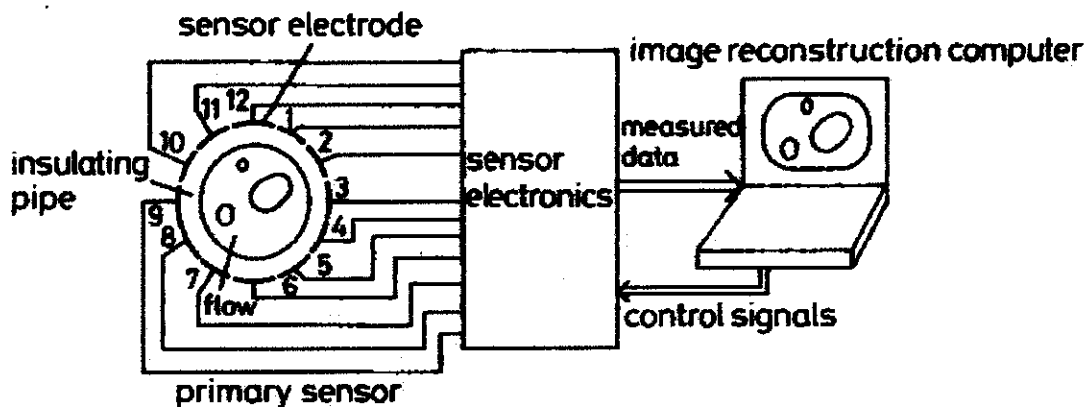


Figure 2.1 Electrical capacitance tomography system

2.2 CAPACITIVE SENSOR

Sensor is a device, which responds to a certain stimulus by an electrical signal. Stimulus is defined as the quantity or condition that the sensor sensed. There are two types of sensor; active and passive sensor. The active sensor depends on the external power for

its operation and then, the signal is modified by the sensor to produce an output signal. For a passive sensor, it is directly generates an electrical signal which has not to rely on any additional energy source.

A variety of sensing methods can be employed on measurements of transmission or electrical phenomena by using radiation, acoustic, or electrical sensors. The sensing system is chosen based on these factors ^[1]:

- The nature of the components (solid, liquid, gas, or the combination of these states).
- The information obtains from the process (steady-state, dynamic, resolution, and sensitivity required) and its purpose (laboratory investigation, optimization of equipment, process measurement, or control).
- Process environment (ambient operation condition, safety implication, and ease of maintenance).
- Size of the process equipment and length-scale of the process phenomena being investigated.

Capacitive sensors operate based on the mechanism of capacitance in between a number of two parallel plates. This type of sensor can be applied in a number of applications; such as in gauge displacement or position, and capacitance measurement for tomography system. The fundamental operating principles for the capacitive sensor rely on the distance between the capacitor plates and the dielectric material of the capacitor.

2.2.1 Principle

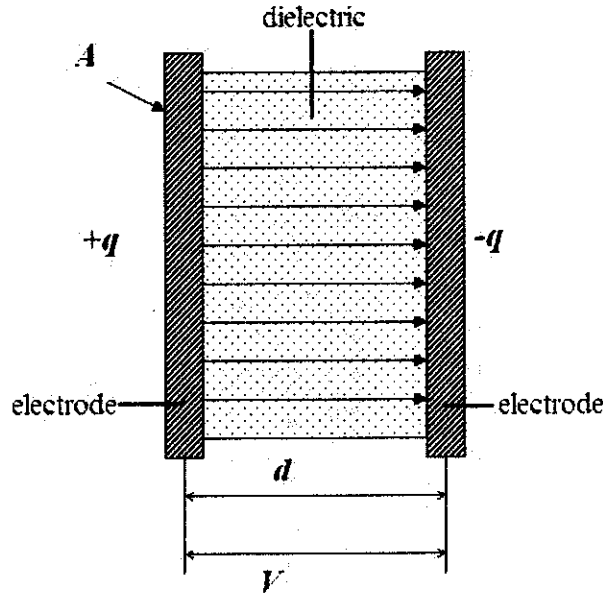


Figure 2.2 Electric charge and voltage define capacitance of a parallel-plate capacitor

A capacitor consists of a pair of plates, which can hold electric charges. The characteristics for the capacitor are the magnitude of charges (q) on both electrodes and the positive potential difference (V) between the electrodes. The ratio of charges to voltage is constant for each capacitor, and it is known as capacitance (C) of the capacitor. Capacitance is defined as the ability of an object or surface to store electrical charges. This ratio can be represented by

$$C = \frac{q}{V} \quad (1)$$

The capacitance is also known as a function of the distance between the two electrodes (d), the area of the plate (A), and the constant (ϵ_r) of the dielectric, which fill the space between the electrodes. The function for these variables is expressed as

$$C = \frac{\epsilon_r \epsilon_0 A}{d} \quad (2)$$

where ε_0 = permittivity constant

$$= 8.854 \times 10^{-12} \text{ F/m}$$

SI unit for capacitance is 1 farad = 1 coulomb/volt which is represented by abbreviation F. In practical, submultiples of the farad are generally used such as

- 1 picofarad (pF) = 10^{-12} F
- 1 nanofarad (nF) = 10^{-9} F
- 1 microfarad (μ F) = 10^{-6} F

2.2.2 Dielectric constant

The dielectric material between the electrodes of the capacitor is characterized by the dielectric constant. The dielectric constant is defined as the reduction in effective field because of the polarization of the dielectric. When the dielectric material is placed between the charged electrodes, the polarization of the medium will produce an electric field opposing the field of the charges on the plate. Therefore, the capacitance value will increase. When the value of the dielectric constant is high, the performance of the electrodes in the capacitor in holding the electric charges also will be better. Some examples of dielectric materials with their constant are shown in Appendix A. The dielectric material must be a good electric insulator as to minimize any DC leakage current through the capacitor.

2.2.3 Sensor characteristics

The electrodes of the capacitive sensors are arranged around the specific object and the capacitances between all the combination pairs of the electrodes are measured in order to build up the 2-D or 3-D images. Generally, for N -electrodes sensor, the numbers of independent measurements (n) are obtained by the combination formula of

$$n = \frac{N(N-1)}{2} \quad (3)$$

In Figure 2.3, it shows an example of twelve electrodes arrangement for the capacitive sensors. The capacitance between the electrodes; [1, 2], [1, 3], [1, 4], and until [11, 12] is measured sequentially with appropriate sensor electronics and the measured values are converted to voltage before they are linked to the image-reconstruction computer.

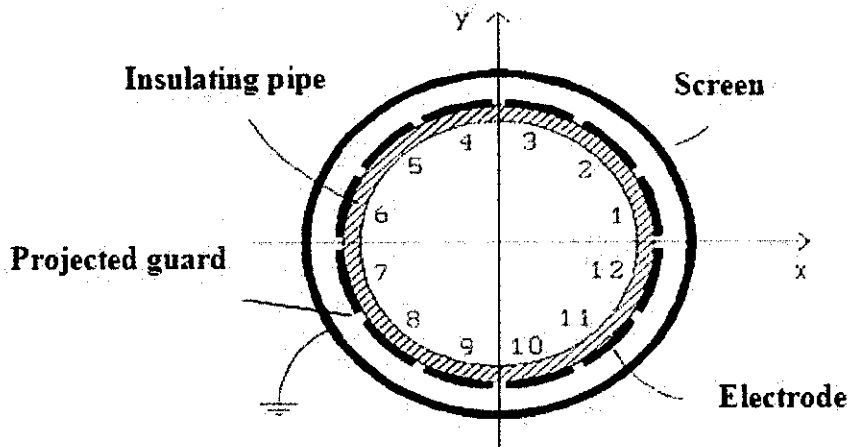


Figure 2.3 Cross-sectional structure of the capacitive sensors

The functions of components in the capacitive sensors are as followed:

- **screen** - to protect the sensor from interferences of external electromagnetic fields.
- **electrode** – to detect the capacitance between two electrodes.
- **projected guard** – to eliminate capacitances between back surfaces of adjacent electrodes and to reduce standing capacitance which insensitive to the dielectric distribution inside pipe liner.
- **insulating pipe** – to separate the material from the electrodes

A few parameters can be highlighted during designing the capacitive sensors, which are:

- the wall thickness of the insulating pipe.
- the gap between the screen and the electrodes.
- the gap between the projected guard with the electrodes.
- the permittivity of the insulating pipe liner.

2.3 DATA ACQUISITION SYSTEM

The basic system of data collection from the sensor is shown in Figure 2.4.

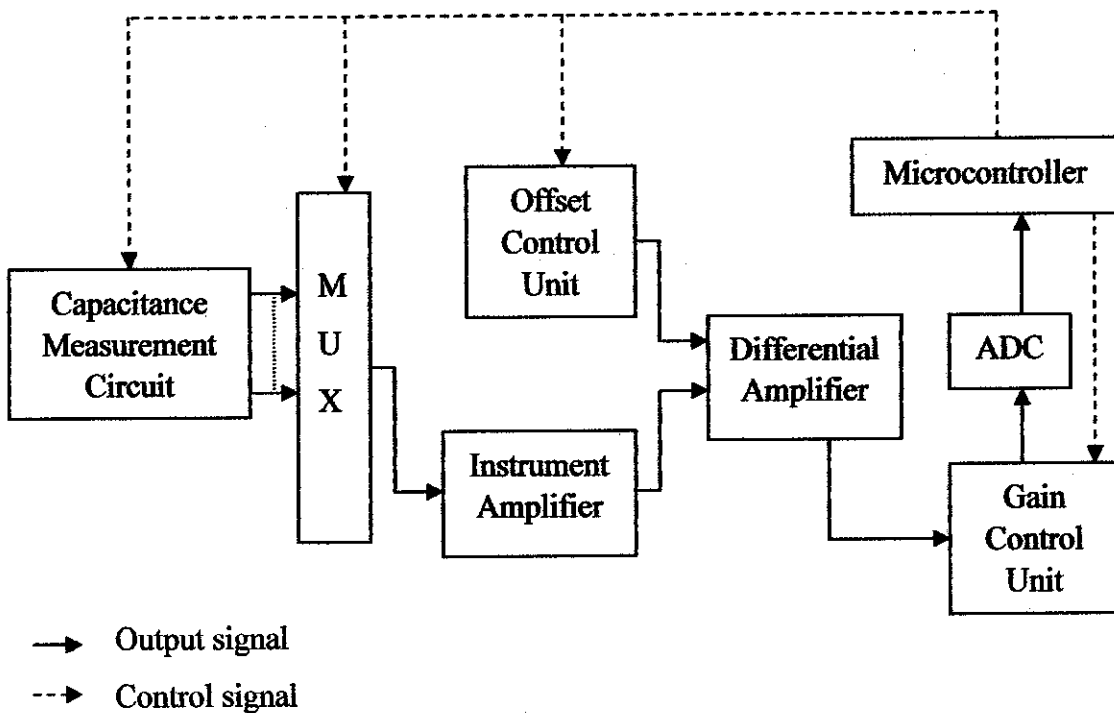


Figure 2.4 Data acquisition system

The major requirement for the capacitance measurement circuit is its sensitivity with the narrow area between the two selected electrodes. Stray-immune circuit satisfies this requirement because it only performs the capacitance measurement between the selected electrodes and insensitive to the stray capacitances either between the selected and the redundant electrodes or between the selected electrode and earth. The examples

of this type of circuit are ac ratio-arm bridges circuit with current detection and switched capacitor charge-transfer circuit. The characteristics for both circuits are shown in Table 2.1.

Table 2.1 Characteristics for the examples of stray-immune measurement circuit

Bridges circuit	Charge-transfer circuit
<ul style="list-style-type: none"> • Operate at frequency lower than a few hundred kHz • Low baseline drift • High signal to noise ratio • A parallel measurement channels with a modulator for each channel will create complexity 	<ul style="list-style-type: none"> • Operate at frequency up to 2 MHz • Faster data-capture rate • Simple circuitry • To increase the speed, a parallel measurement channels could be used with low cost and no complexity

2.3.1 Amplifiers

Amplifier is composed with standard building blocks, such as operational amplifier (op-amp) and various discrete components (semiconductor, resistor, capacitor, and inductor). The functions of the amplifier are:

- to increase the signal amplitude (signal conditioning).
- to enhance the magnitude of the signal to noise ratio (SNR).
- as an impedance matching device.
- as an isolator between input and output.

For an op-amp with no feedback component, it is known as open-loop condition. In open-loop condition, the open loop gain (A_{OL}) is not a stable parameter. The gain changes with load resistance, temperature, and power supply fluctuation. However, an op-amp is rarely used without the feedback components because when A_{OL} is high, it may result in circuit instability, a strong temperature drift, and noise. The linearity, gain

stability, output impedance, and gain accuracy are improved by an amount of feedback and also depend on the characteristics of the feedback components.

2.3.2 Charge amplifier circuit

Charge amplifier (CA) circuit has extremely low bias current, which operates by producing charges that are proportional to the measurement variable and the charges can be converted into voltage. A basic circuit of a charge amplifier is shown in Figure 2.5.

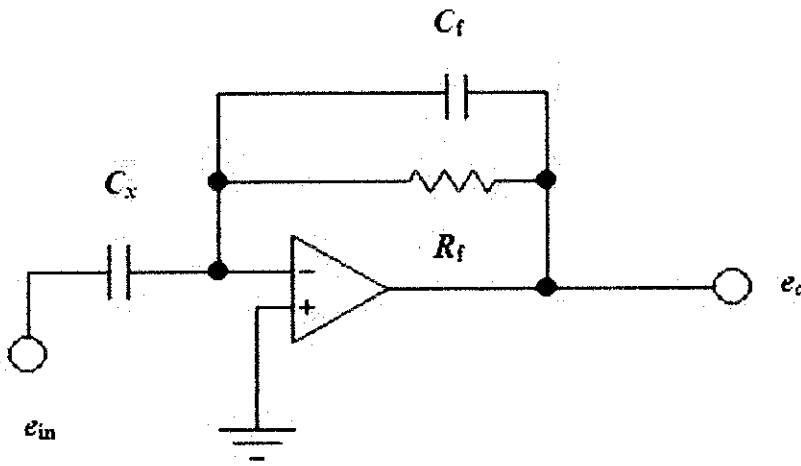


Figure 2.5 Charge amplifier circuit as charge-to-voltage converter

The charge amplifier circuit consists of a capacitor (C_f) that is connected into a feedback network of an op-amp. Its leakage resistance (R_f) which is in parallel with C_f , must be larger than the impedance of the capacitor at the lowest operating frequency^[3].

Generally, the amplifier gives an output signal:

$$e_o = -\frac{C_x}{C_f} e_{in} \quad (4)$$

where; e_o = output voltage signal

e_{in} = input voltage signal

C_x = generated capacitance

C_f = feedback capacitance

CA is applied to provide a DC path for amplifier bias current. Without the R_f in the circuit, C_f will continue charging and then affect the output to drift into saturation [2].

The input stage of CA features a capacitive feedback connection, which balances the effect of the applied charge input signal. The feedback signal represents as the input charge, q_{in} . q_{in} is injected to the summing point (inverting input) of the amplifier. It is distributed to the cable capacitance (C_c), amplifier input capacitance (C_{inp}), and feedback capacitance (C_f). Therefore, the node equation of the input is:

$$q_{in} = -(q_c + q_{inp} + q_f) \quad (5)$$

By using the electrostatic equation $q = VC$ and substitutes q_c , q_{inp} , q_f , and V_{inp} as the input voltage of the CA:

$$q_{in} = -[V_{inp} (C_c + C_{inp}) + V_f C_f] \quad (6)$$

Since the voltage difference between the inverting and the non-inverting input of a differential amplifier becomes zero under normal operating conditions, this can be assumed, as the V_{inp} equals to GND potential. With $V_{inp} = 0$, the equation might be simplified with:

$$q_{in} = -V_f C_f \quad (7)$$

Solving for the output voltage, V_{out} which also equals to the feedback voltage, V_f .

$$V_{out} = V_f = -\frac{q_{in}}{C_f} \quad (8)$$

The result shows that the output voltage of a CA depends only on the charges input and the feedback capacitance and it also the same with equation 4. Input and cable capacitances have no influence on the output signal.

2.3.3 Analog to Digital Converter

Analog to digital converter (ADC) is applied as to digitize the final signal from the gain control unit. PIC16F877 as shown in Figure 2.6 is going to be applied at the end of data acquisition system before the output signal is sent to the computer. PIC16F877 is a high-performance FLASH microcontroller that provides the high design flexibility. PIC16F877 features an integrated 8-channel 10-bit ADC. Peripherals include two 8-bit timers, one 16-bit timer, Watchdog timer, Brown-Out-Reset (BOR), In-Circuit-Serial Programming™, RS-485 type Universal Asynchronous Receiver/Transmitter (UART) for multi-drop data acquisition applications, and 12C™ or SPI™ communications capability for peripheral expansion. Precision timing interfaces are accommodated through two Command Control Processor (CCP) modules and two Pulse Width Modulation (PWM) modules [6].

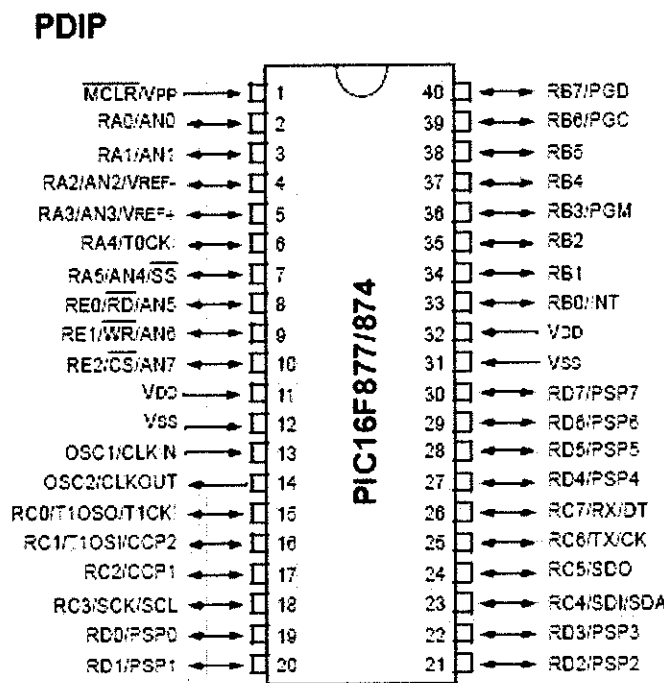


Figure 2.6 Microcontroller 16F877

2.4 IMAGE RECONSTRUCTION SYSTEM

The data presented to the computer are as an array of numbers which are related to the capacitance measurements taken between two electrodes. Linear Back Projection (LBP) Algorithm has been considered as one of the method to develop the image. From LBP algorithm, the normalized capacitance measurements are weighted by a predetermined sensitivity distribution function and back projected on to the object cross-section.

CHAPTER 3

METHODOLOGY

This project will be implemented in duration of 2 semesters. To be accomplished, this project will need several methods. Therefore, the project will be implemented by stages as listed below:

- First semester: Literature review / research / data gathering / circuit design / testing / analysis
- Second semester: circuit design and improvement / computer-device communication development / testing / analysis

3.1 LITERATURE REVIEW AND RESEARCH

Literature review and research will be done by obtaining the information through books, internet, and journals. These stages provide the important and useful knowledge for next step; the design stage.

3.2 CIRCUIT DESIGN

The design of capacitance measurement circuit is based on the switching period of charges and discharges the unknown capacitor (C_x) and also how to measure the charges from the capacitor. This design is based on the charge-transfer circuit design which has more advantages compare to the bridges circuit as mentioned in Table 2.1. The capacitance measurement circuit applies CA to convert the charges from into the voltage signal. This CA is designed refers to the output equation of the amplifier circuit.

There are two main components for the CA; R_f and C_f . The presence of R_f limits the lower bandwidth of the CA to a frequency, f_L given by the equation:

$$f_L = \frac{1}{2\pi C_f R_f} \quad (9)$$

A high value of R_f is required if the output is to reproduce slow changes in the measurement variable ^[2]. Therefore, R_f is set to be

$$R_f \approx 100 Z_{C_f} \quad (10)$$

$$f_o \approx \frac{100}{2\pi C_f R_f} \quad (11)$$

The operating frequency, f_o is applied with a higher value than the f_L to obtain a stable DC output voltage. This condition requires a high speed of op-amp which its transient frequency, f_t is

$$f_t \approx 100 f_o \quad (12)$$

The switching circuit of the switched capacitor charge transfer circuit is designed based on the charging and discharging stages of C_x . These stages are related to the RC time constant, τ which is the time for a capacitor to charge and discharge an amount of capacitance. This time constant relates with the time require for a capacitor to charge up to 63.2% of the applied voltage or discharge down to 63.2%. Usually the value of τ is equal to the value RC . For the capacitance measurement circuit, τ will be influenced by the $R_f C_f$ in the CA circuit. A capacitor normally takes 5τ to charge and another 5τ to discharge. In the capacitance measurement circuit, four switches will be applied, which are connected to the source and detecting electrodes. Two switches are ON during charging period of C_x and another two are ON during discharging it.

3.3 EXPERIMENTAL

The design of capacitance measurement circuit is tested by using the values of the resistors and capacitors for the feedback components, which are obtained from the calculation, with a number of known capacitance values as the C_x . The output signals of the CA are observed. The observations from the experiment are analyzed to ensure the calculation values for the output voltage are the same as the output measured. Function generator, DC power supply, multimeter, high-speed op-amps, CMOS quad bilateral switches, resistors, multiplexer, capacitors, logic gates, and J K flip flop are used during the experiment.

3.4 ANALYSIS

The results from the tested circuit are analyzed by comparing the calculated values with the experimental values to prove that the circuit is able to operate as a capacitance measurement circuit. If the comparison raises a lot of differences, the circuit design is altered by using new values of components obtain from the calculation. The analysis is continued until the best design of capacitance measurement circuit is achieved.

3.5 COMPUTER-DEVICE COMMUNICATION DEVELOPMENT

During the hardware development, 2 major types of programming are used; C language for the microcontroller and the interface programming. The microcontroller is programmed due to convert the analog signal from the data acquisition system to the digital signal before the signal is transmitted to the computer. For interface programming, Visual Basic 6.0 programming is applied as to develop the communication between the hardware and the computer.

3.6 COMISSIONING AND VERIFICATION

After completing those procedures, the next step is commissioning. During this level, the verification and device 'test run' are carried out. This procedure will ensure that the device can work properly and withstand various conditions. The steps involve for this procedure are component assembly, test run, and trouble shoot.

CHAPTER 4

PROJECT WORK

4.1 HARDWARE

This project requires on designing the hardware system for the ECT. It consists of the capacitance electrodes, capacitance measurement circuit, multiplexer, instrument amplifiers, differential amplifiers, charge and discharge control circuit, offset control unit, gain control unit, control logic, and PIC microcontroller.

4.1.1 *Sensor system*

Capacitance sensors consist of a pair of selected electrodes which is controlled by the switching circuit via two pairs of CMOS switches. The capacitance between the selected electrodes is measured by the capacitance measurement circuit. For a complete sensor system, an even number of electrodes are arranged peripherally of an object.

Firstly, the known values of capacitor (1-10pF) are used which represent as a pair of electrode in the sensor system. These capacitors are connected one by one to the capacitance measurement circuit as to observe the circuits' performance when the values of the capacitor are varied. After the performance is analyzed, a prototype of 4 electrodes sensor system (Figure 4.1) is constructed in order to repeat the same analysis with known capacitors. The capacitance for a pair of electrode depends on the distance between those electrodes. The capacitance between adjacent electrodes are higher than the opposite electrodes but the capacitance of electrodes 1 and 2; and 1 and 4 might not be the same due to the stray capacitance from the measurement circuit and also the

interference from the external electromagnetic field from surrounding. To reduce the interference of electromagnetic field, a prototype for 8 electrodes (Figure 4.2) is designed with an earthed screen around the electrodes. The electrodes are arranged alternately with projected guard to ensure that these electrodes will not touch each other and to reduce any stray capacitance contribute by the adjacent electrodes.

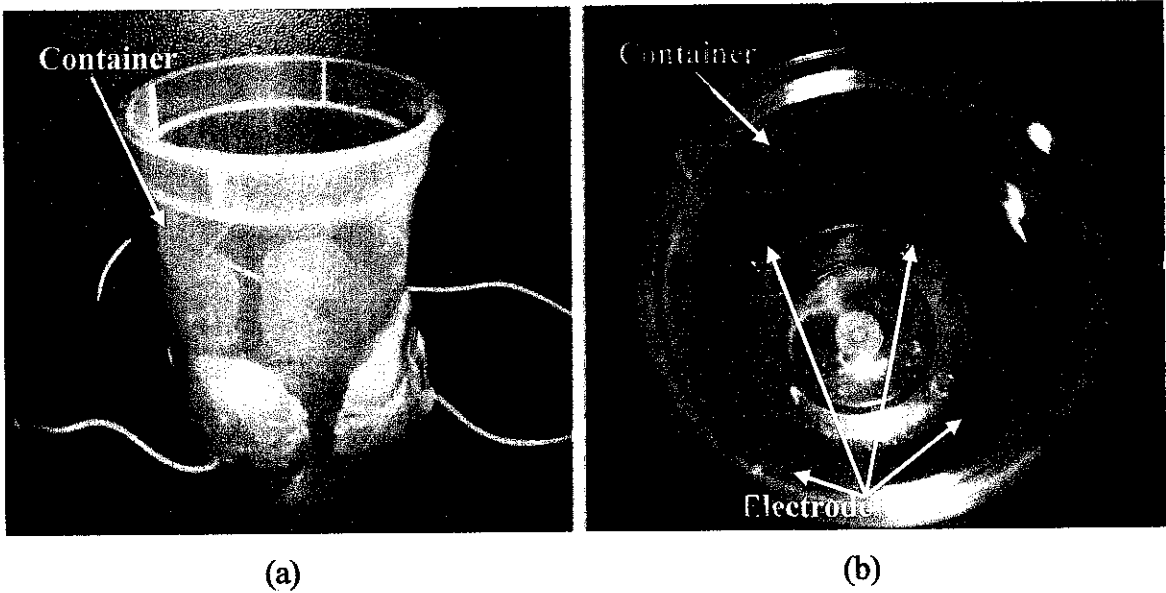


Figure 4.1 Sensor system with 4 electrodes: (a) opposite view, (b) top view

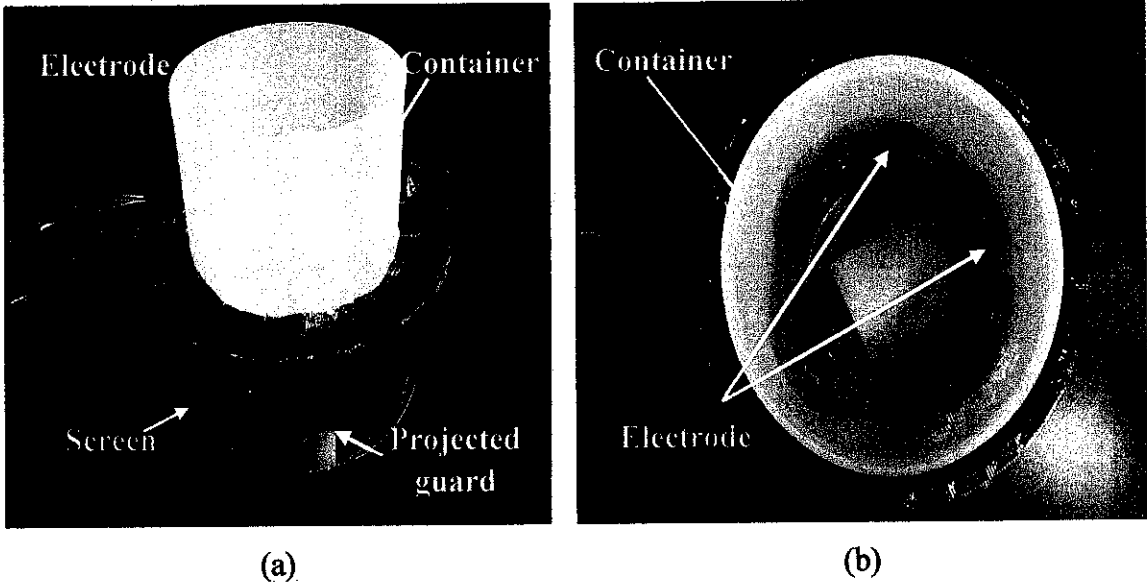


Figure 4.2 Sensor system with 8 electrodes: (a) opposite view, (b) top view

4.1.2 Capacitance measurement circuit

The measurement circuit is based on the charge transfer circuit and charge amplifier circuit. The charge-transfer circuit provides a fast data capture rate and it also simpler compares to bridge circuit. The performances of charge-transfer circuit which are represented by the CMOS switches in the circuit are as follows:

- The operation will be repeated at an operating frequency, f_o of the circuit. This frequency also known as the sampling frequency of the circuit.
- The sampling frequency is chosen so that:

$$f_s > 2f_x \quad (13)$$

where f_x is the frequency of C_x .

- The charge amplifier circuit is designed to have a low-pass bandwidth which satisfies:

$$f_o < f_s - f_x \quad (14)$$

- C_{in} is the capacitor uses to ensure the virtual earth potentials at the charge amplifier circuit remain stable during the high-speed charge and discharge stages.
- By choosing large integration time constant, $T_f = R_f C_f$ and large value of C_{in} , the charge measurement circuit will produce a DC output voltage proportional to the C_x .

- The output voltage of the charge measurement circuit is given by:

$$V_o = f_s V_c R_f C_x \quad (15)$$

Charge amplifier is a part of the charged-transfer circuit, which reacts as the converter to convert the generated charges from the capacitive sensors to voltage signal which operates at certain frequency. The switching circuit is connected to the CA circuit as to control the charging and discharging stages of the C_x .

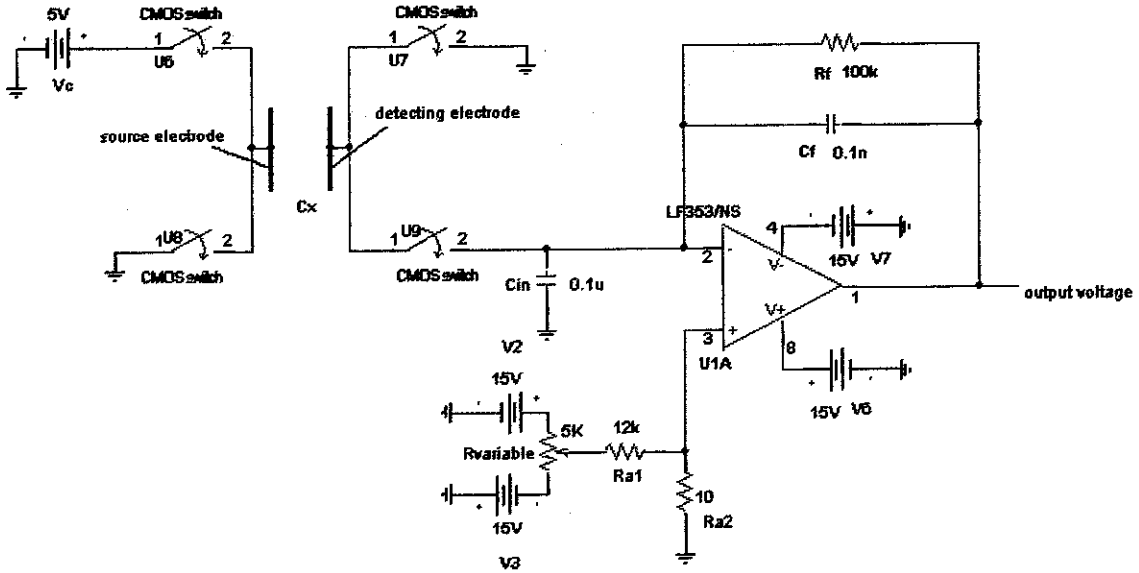


Figure 4.3 Capacitance measurement circuit

During designing the circuit, a few points are highlighted as to obtain the exactly values for the components for operating it in high speed.

- The CA circuit is conducted at frequency 10^6 for higher sensitivity.
- The value of C_f must be very small so it can measure C_x in small range.
- Its R_f which is in parallel with C_f , must be larger than the impedance of the C_f .

Thevenin theorem is used to eliminate the offset voltage at the noninverting input of the op-amp:

$$\text{Given } V_{ios} = 10\text{mV}$$

$$V = |V_{cc}| = |V_{ee}| = 12\text{V}$$

$$R_{pmax} = \frac{R_p}{2} \parallel \frac{R_p}{2} = \frac{R_p}{4}$$

$$\frac{V}{V_{ios}} = \frac{R_{a1}}{R_{a2}} = \frac{12}{10\text{m}} = 1.2\text{k}$$

$$R_{a2} < 100\Omega$$

$$\text{Therefore, } R_{a2} = 10\Omega, R_{a1} = 12\text{k}\Omega$$

$$R_{pmax} = \frac{R_{a1}}{10} = 1.2\text{k}\Omega$$

$$R_p = 4 \times R_{pmax} = 4.8\text{k}\Omega$$

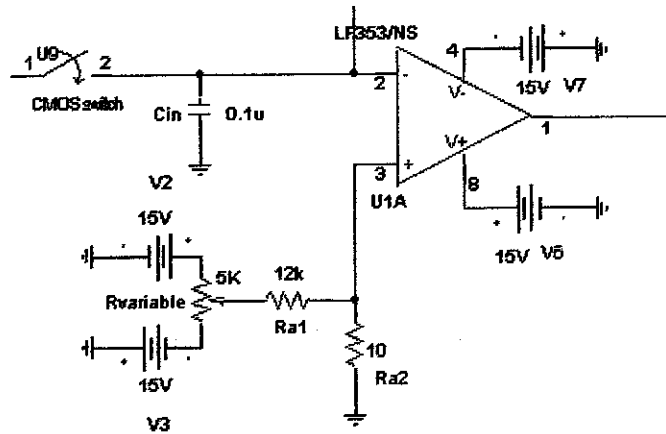


Figure 4.4 Compensation network: eliminate the offset voltage

4.1.3 Multiplexer

For this design, multiplexer is used to select only one measurement output from the measurement circuits at a time before the signal is digitized by the ADC. After all measurements are completely convert to digital signal, then all the data will be sent to the computer. IC CD4051B is applied to the circuit as the multiplexer.

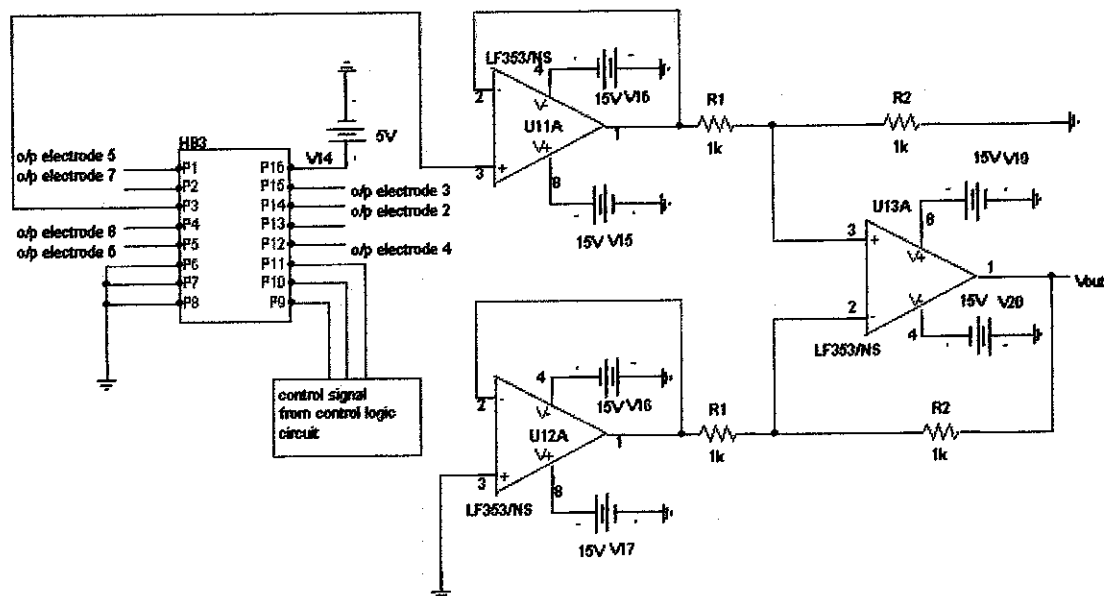


Figure 4.5 Multiplexer connected to the instrument and differential amplifier

4.1.4 Instrumentation amplifier and differential amplifier

An instrumentation amplifier is a type of op-amp that has been specifically designed to have characteristics suitable for use in measurement and test equipment. This op-amp is applied when accuracy and stability of the circuit are required. Along in the instrument amplifier is differential amplifier. The differential amplifier amplifies the difference between two input signals (-) and (+). This amplifier is also referred to as a differential-input single-ended output amplifier. It is a precision voltage difference amplifier, and forms the central basis of instrumentation amplifier circuits. This differential

amplification also been applied as the first stage of op-amps. The output equation for the circuit in Figure 4.2 is as follows:

$$V_{out} = (V_2 - V_1) \frac{R_2}{R_1} \tag{16}$$

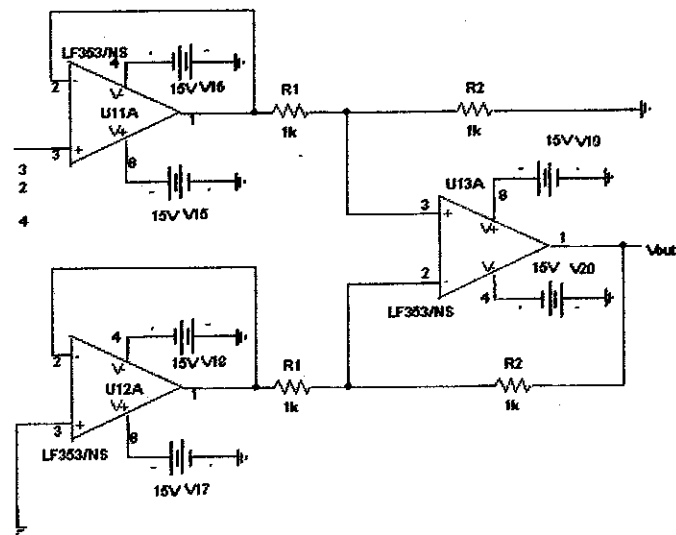


Figure 4.6 Differential amplifier with buffer amplifiers

4.1.5 Offset and gain control units

Offset control unit is established as to correct the drift by subtracting the baseline from the values measured afterwards. The offset value which is obtained during the calibration of the mesurement circuit is subtracted from each measurement value after the check. The calibration procedure is performed before the measurement and imaging process. The procedure is described from block diagram in Figure 4.7.

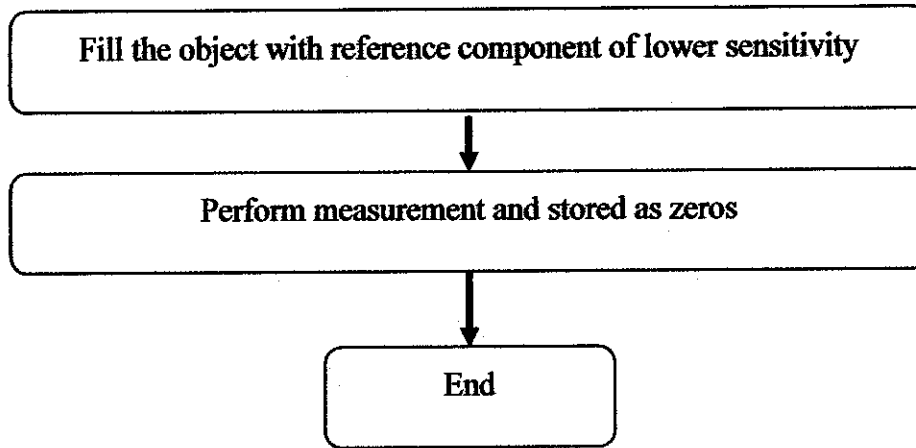


Figure 4.7 Calibration procedure

Gain control unit functions as to amplify the output signal with the selectable gains. Therefore, the output signal will deal with the large measurement range ^[7].

4.1.6 Analog to digital converter

PIC16F877 microcontroller circuit at the end of data acquisition circuit is able to convert the analog signal of the measurement to the digital signal before the output is transmitted to the computer for image reconstruction. The microcontroller needs to be programmed by using C language. The programmed codes are downloaded via MPLab software by using WARP13 external device.

PIC16F877 works on a 10-bit digital number. The 10-bit A/D data is loaded onto the register pair ADRESH:ADRESL which is a 16-bit wide register pair. The A/D module has a high reference voltage of 5V and a low reference voltage of 0V. Therefore, the analog input must be varied between the ranges of 0 to 5V. An example to convert the corresponding voltage to a hexadecimal number is as shown below:

Since the maximum voltage allowed is 5V, the corresponding 10-bit binary number will be:

$11\ 1111\ 1111_2$ is equal to 1024_{10} .

This is the base ration for the next voltage value.

Eg:

Input voltage = 3.75 V

$$3.75V \times \frac{1024_{10}}{5V} = 768_{10}$$

Therefore, 768_{10} is equal to $11\ 0000\ 0000_2$.

This microcontroller also uses as the part of serial communication to the computer. The programming is designed to select one by one the output signal to be transfer to the computer as in serial output.

4.1.7 Control logic circuit

The switching circuit and multiplexer is controlled via control logic by using J-K flip-flop integrated circuit (IC) and logic gates. The gates IC consist of AND and OR gate. The state transition diagram is applied to obtain how many states are required for the counter flip-flops change with each applied clock pulse. State transition diagram is used as to analyze, and design counters and other sequential circuits. The state transition diagram is illustrated in Figure 4.8. From the figure, each circle represents one possible state as indicates by the binary number. The arrows connecting the circles show one state changes to another as a clock pulse applied.

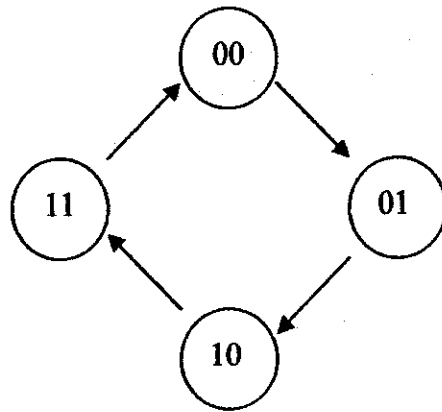


Figure 4.8 State transition diagram

The sequence circuit of the state transition diagram is developed by using the sequential circuit design method. This method involves the design of synchronous counter and logic circuit as to decode the various states of the counter to supply the logic level to each J and K input. The inputs to the decoder circuits will come from the outputs of the flip-flops. The Excitation Table (Table 4.1) is used to determine the J and K levels require producing any transition at the output.

Table 4.1 J-K flip-flop Excitation Table

Transition at output	PRESENT state Q(N)	NEXT state Q(N+1)	J	K
0 → 0	0	0	0	x
0 → 1	0	1	1	x
1 → 0	1	0	x	1
1 → 1	1	1	x	0

The signal for the charge and discharge switches, control signal for the multiplexer, and inhibit signal for the multiplexer are obtained from the output of the J-K flip-flop. The output signal of J-K flip-flop will be either connected directly or connected to logic gates first as to obtain the specific control signal for control input of both switches and multiplexer. The Karnaugh map (K map) is applied during logic control design as to simplify the logic equation and to convert the truth table to its corresponding logic

circuit in a simple process.

4.1.8 Communication circuit between hardware and computer

PIC16F877 microcontroller circuit is constructed to establish the communication between the hardware of ECT system to the workstation (computer). This microcontroller is programmed to read the output measurement from the data acquisition system. MAX232 integrated circuit also included with the connection of PIC16F877 as to control the communication of the serial communication. It either can be as a driver or receiver to the serial port of the computer. MAX232 also helps protect the processor from possible damage by static that may come from people handling the serial port connectors. Therefore, it is needed to establish the communication between the device, processor, and RS232 serial port.

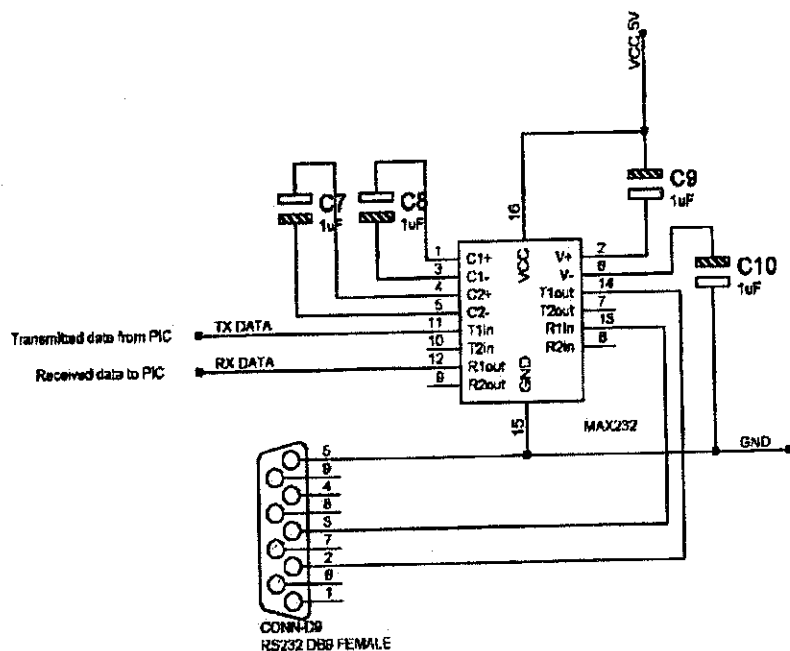


Figure 4.9 The connection between RS232 serial ports with MAX232

4.2 SOFTWARE

Mainly the software system is the visualization of the measured signals from the hardware system which are stored into the computer. For the image reconstruction, Linear Back Projection (LBP) Algorithm, Linear Forward Projection (LFP), and Finite Element Method (FEM) can be employed for the real time visualization.

4.2.1 Image reconstruction programming

FEM is based on the electrostatic field theory which investigates the complex capacitor sensor configuration. Then, it will model the pattern by dividing the cross section into P quadrilateral elements corresponds to the Q nodes. The resultant nodal potential will be used to determine the capacitance between electrode pair i-j by performing:

$$C_i = -\frac{1}{V} \int_{L_i} \epsilon(x, y) \nabla \phi(x, y) d\vec{l} \quad (17)$$

V = voltage at source electrode

L_i = curve encompassing the detecting electrodes

$\Phi(x, y)$ = depends upon the dielectric distribution

FEM will represent the pipe cross-section as an array of sensitivity values:

- Each value will correspond to the magnitude of capacitance change at the pixel (p).
- $S_{ij}(p)$ is the precalculated of the sensitivity matrix
- $G(p)$ is the grey level of the image
- $\lambda_{i,j}$ is the normalized capacitance measurement

From equation 18, the first image is reconstructed from the value of the measured capacitance and the sensitivity matrix.

$$G^{(0)} = SC \quad (18)$$

The sensitivity matrix is performed by:

$$S_{i,j}(p) = \frac{C_{i,j}(p) - C_{i,j}(\text{empty pipe})}{C_{i,j}(\text{full pipe}) - C_{i,j}(\text{empty pipe})} \quad (19)$$

Next image is obtained from the iterative process. The capacitance is estimated from current image $G^{(k)}$ and sensitivity matrix ,S by applying the LFP algorithm.

$$G^{(k+1)} = G^{(k)} + \alpha S(C - SG^{(k)}) \quad (20)$$

α = step length

CHAPTER 5

RESULT AND DISCUSSION

During the project commissioning, some experiments are carried out to obtain the results with high efficiency and reliability. According to the requirement, the experiment is performed by using the known values of C_x in order to observe the linearity of the output. As long as the output voltage is proportional to C_x , the result is acceptable. The circuit for this experiment is shown in Figure 5.1.

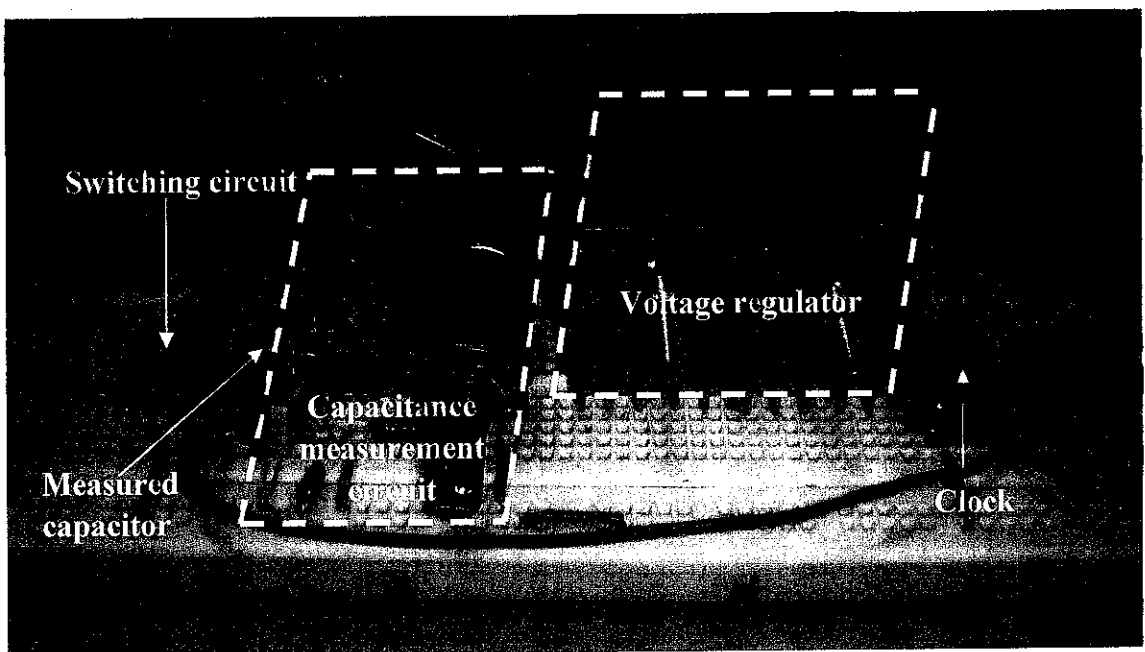


Figure 5.1 Test circuit for capacitance measurement

The conditions for each experiment are listed in Table 5.1. The output graph for each result is illustrated in Figure 5.2. The conditions for each experiment are based on these settings:

Table 5.1 Conditions for each experiment

Condition	$C_f(\text{pF})$	$R_f(\text{M}\Omega)$	$f_s(\text{kHz})$
A	0.5	50	16
B	0.5	50	32
C	0.5	50	32
D	0.5	50	64
E	0.5	50	64
F	0.5	50	128
G	0.5	50	250
H	0.5	50	500
I	0.5	10	500
J	0.5	50	1000
K	0.5	10	1000

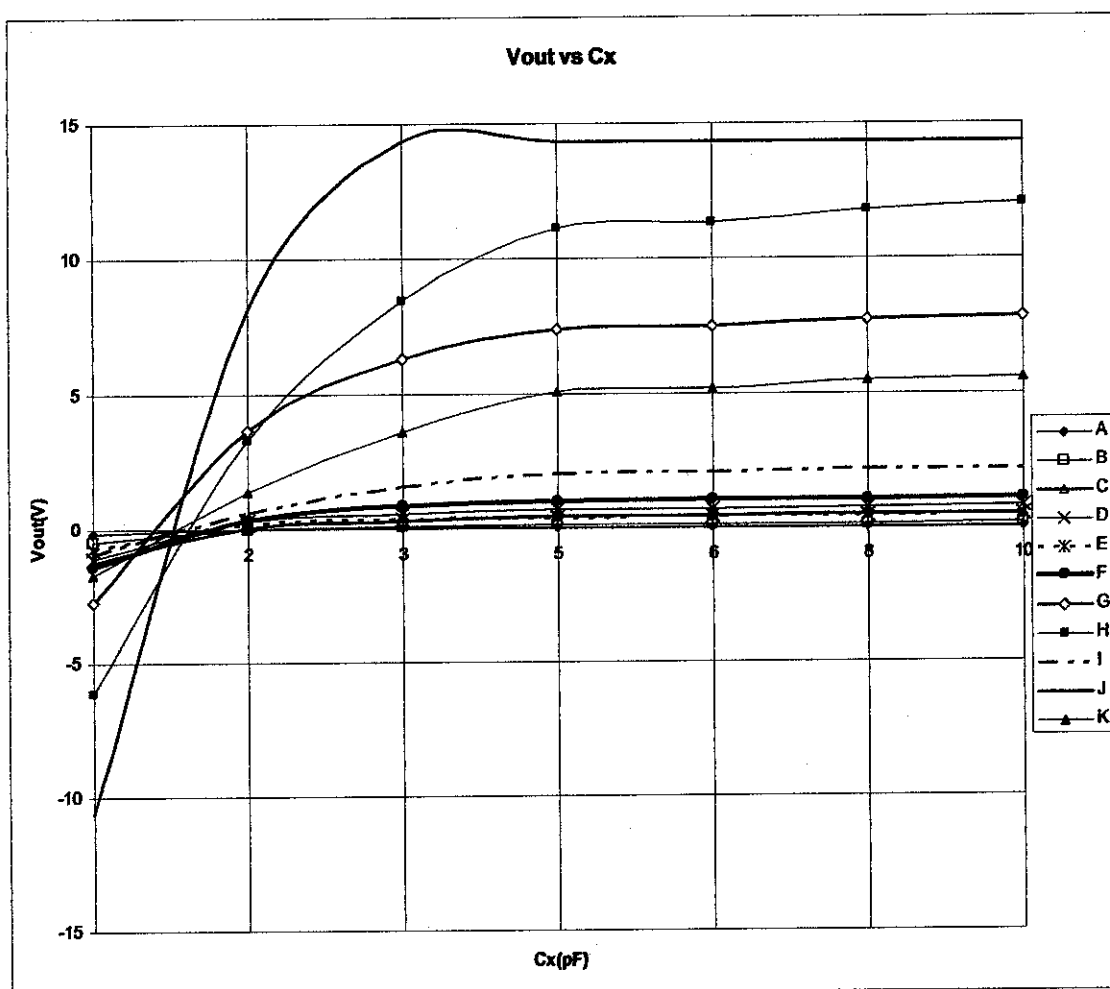


Figure 5.2 The linear response of output voltage vs known capacitor, C_x

In this experiment, the outputs are not stable when f_s are higher than 64 kHz. For capacitance measurement circuit, it is required to operate in high frequency as to increase the sensitivity of the circuit with the output measurement. From those results, the circuit is reconstructed to increase the accuracy of the output in high operating frequency. The values for new circuit design of capacitance measurement circuit are listed in Table 5.2. The graph of output voltage vs C_x is represented in Figure 5.3.

Table 5.2 Results of output voltage (mV) for $C_f = 0.1\text{nF}$, and $f_s = 1\text{MHz}$

$C_x(\text{pF})$ $R_f(\Omega)$	1	2	3	5	6	8	10
100k	34.8	510.6	885.7	2030	2310	3550	4300
51k	22.9	266.8	458.2	1040	1170	1810	2180
43k	20.2	235.2	404	915	1020	1560	1920
36k	11.4	185.6	322.7	740	846	1290	1560
24k	15.5	132.2	223.5	501.9	562.7	865.7	1050
12k	12.7	71.5	117.4	257.2	286.7	440.4	530.9
1k	9.57	14.5	18.3	29.9	32.3	45.2	52.7

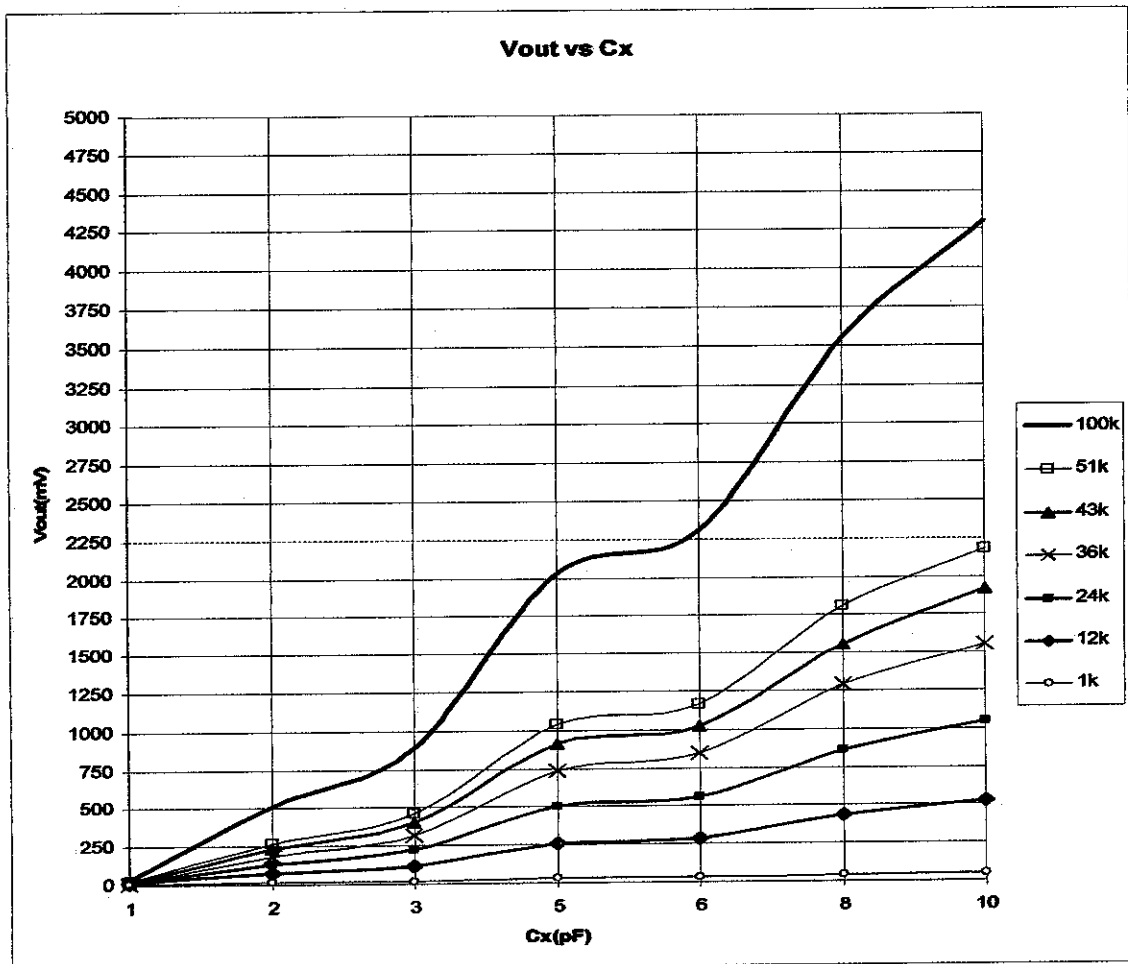


Figure 5.3 Positive linear response for output voltage vs known capacitor, C_x

Based on Table 5.2 and Figure 5.3, the results show that when the value of R_f is increased, the output voltage will give more difference between the reading when the value of C_x is changed. Therefore, if there is any capacitance change in the target object, the circuit will be capable to give a big difference in the output voltage.

This capacitance measurement circuit on the breadboard is tested with 4 electrodes system and the output voltage is measured manually using digital multimeter. The output voltage is quite small compared when the circuit is tested with known capacitor. This condition happens due to the effect of stray capacitance from the wiring and the circuit itself. Therefore, the sensor system is tested with printed circuit board (PCB) by using circuit as in Figure 5.4 and the output voltages are compared with the previous measurement. The result is shown in Figure 5.5.

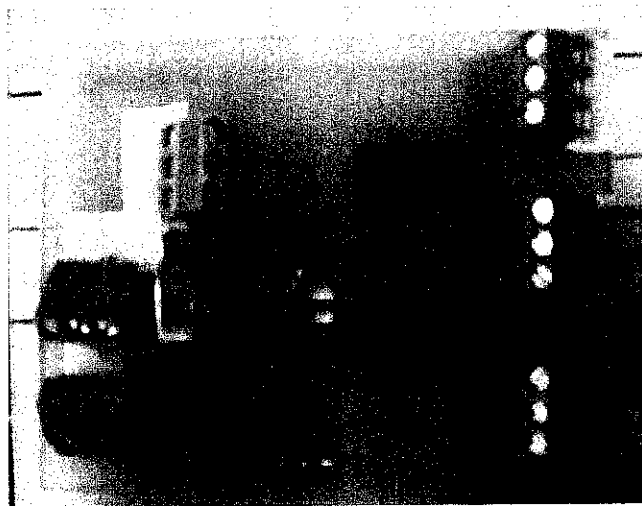


Figure 5.4 Capacitance measurement circuit on the PCB

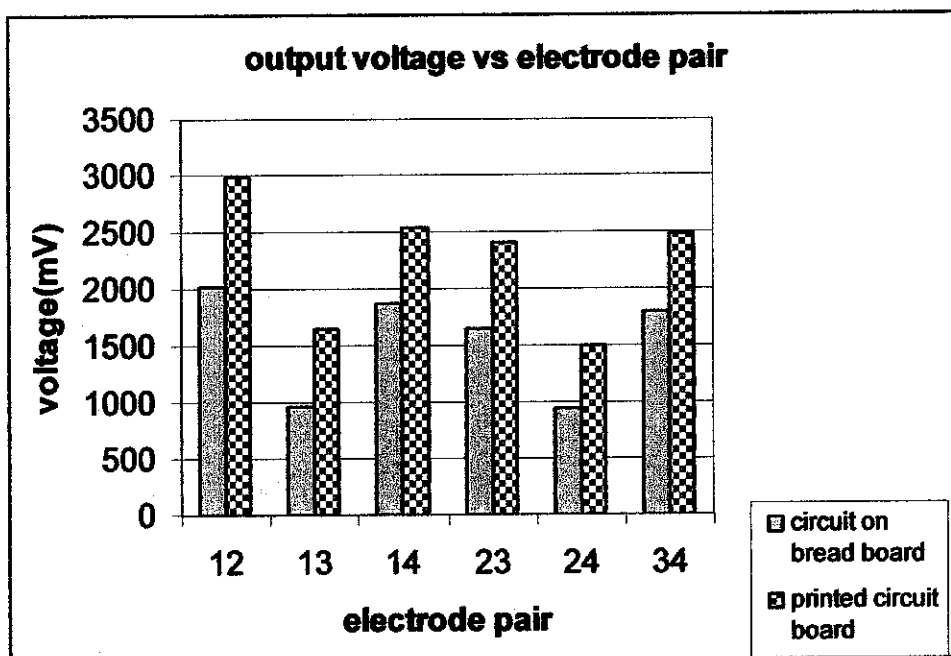


Figure 5.5 Comparison of output voltages from circuit on the breadboard and PCB

Based on Figure 5.5, the effect of stray capacitance from the wiring can be reduced by designing the circuit on a PCB. This method will reduce the stray capacitance because of the large earth plane on the printed board. The efficiency of the measurement circuit also increases due to the high sensitivity of the circuit to the small changes in the measured capacitance.

The capacitance measurement circuits are tested with the 8 electrodes capacitive sensor for observing the circuits' sensitivity with the measured capacitance. The sampling test is conducted twice with electrode 1 as the source electrode and the other electrodes as the detecting electrodes. Therefore, there will be 7 measurements obtained during the sampling test. The output voltages for the sampling test are illustrated by the bar graph in the Figure 5.6.

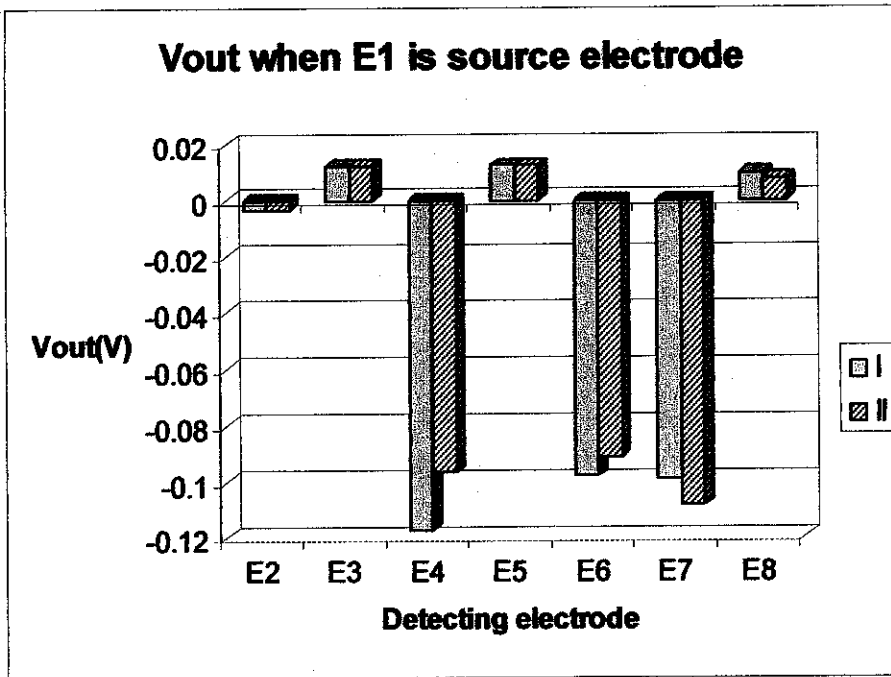


Figure 5.6 Output voltage for 8 electrodes capacitive sensor

From Figure 5.6, it shows that the output voltage for both sampling times are quite similar, means that the time delay that contributes from the components are quite small and do not bring big effect for sampling the output voltage. The negative values of the output voltage represent that the measurement is conducted at very low sampling frequency so it requires conducting the sampling at higher frequency as to increase the sensitivity of the measurement circuit.

The control logic circuit is designed based on the sequential circuit design method. The truth table of controlling the circuit for sampling test is attached in Appendix C. This design process involves the transition diagram from state 0000 to state 1111. After that, the Excitation Table (Table 4.1) is referred to build the truth table for the J-K flip flops transition level. From this truth table, the K map method is applied as to simplify the corresponding logic circuit. As the result, the control signal for inputs of flip-flops, multiplexer control, and switches are as follow:

- J-K flip-flops
 - $J_{Q0} = 1, K_{Q0} = 1$
 - $J_{Q1} = Z, K_{Q1} = Z$

- $J_{Q2} = YZ, K_{Q2} = YZ$
- $J_{Q3} = XYZ, K_{Q3} = XYZ$
- Multiplexer
 - $A = Y$
 - $B = \overline{W}X + W\overline{X}$
 - $C = W$
- CMOS switches (S_{xS} = source switch, S_{xG} = ground switch, S_{xM} = measurement switch)
 - Electrode 1
 - $S_{1S} = \overline{Z}$
 - $S_{1G} = Z$
 - Electrode 2, 3, 4, 5, 6, and 7
 - $S_{xS} = 0$
 - $S_{xG} = \overline{Z}$
 - $S_{xM} = Z$
 - Electrode 8
 - $S_{8G} = \overline{Z}$
 - $S_{8M} = Z$

To obtain the best design of hardware system for the 8 electrodes sensor system, the measurements circuit is tested with only two complete cycles of measurement with electrode 1 is the source electrode. The sampling time for the measurement is important because of the measurement from each detecting electrode happens in 0.5us. Therefore, the sampling time for the output must be faster enough. Latching method is applied as to hold first the output values in digital form before it is transmitted to the computer. The hardware system for the ECT is referred in Figure 5.7.

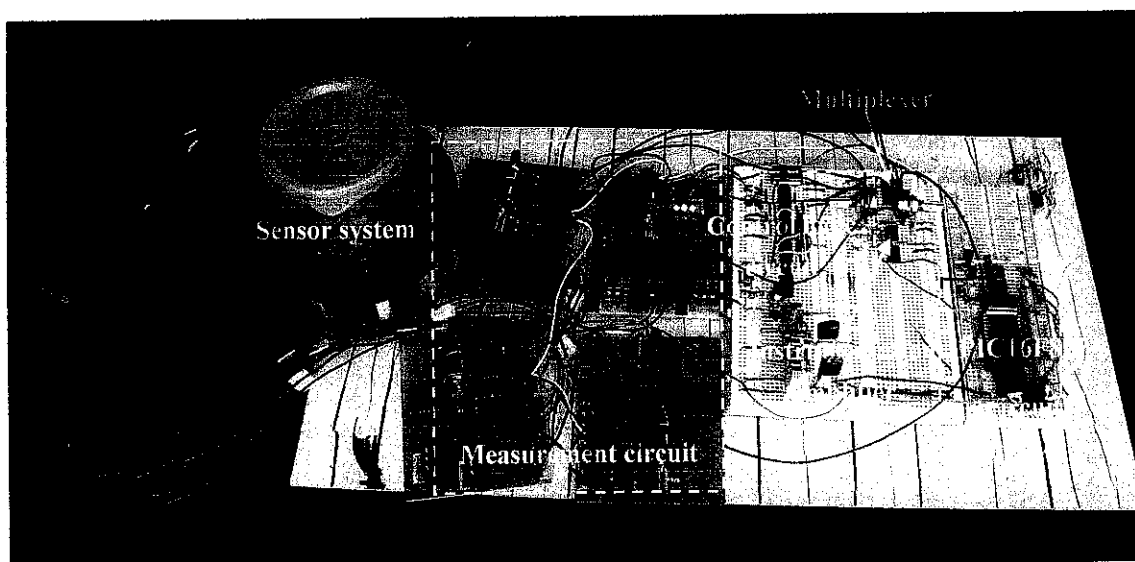


Figure 5.7 Hardware system of ECT

CHAPTER 6

CONCLUSION AND RECOMMENDATION

6.1 CONCLUSION

As the conclusion, the project brings the opportunity to learn and develop the capacitive sensors system base on from the literature review and research which have been done before. This hardware part exposes the student in circuit design and gain experiences in troubleshoot the circuit. From the experiment of circuit measurement circuit, the charge-transfer circuit can be used as the one of the main circuit to measure the capacitance in term of voltage. High operating frequency of the op-amp and ceramic capacitors are used to obtain a good result from the experiment. The components also need to be examined first before starts the experiment to ensure all of them are working when they are connected to the power supply.

The limitation in designing the circuit is to find the op-amps which capable to operate with high frequency. This first design of capacitance measurement circuit only capable to measure the C_x from 1nF to 0.1nF only. This condition happens because of the operating frequency is bigger than the transient frequency of the op-amp. The operating frequency of this circuit must be 100 times less than the transient frequency. Due to this limitation, op-amp LF353 and with new values for other components are used for the measurement circuit. By using this design, the circuit is capable to measure from 1pF to 10pF. To increase the sensitivity of the circuit, it is designed on the PCB with large earth plane.

The sampling time to transmit the measured output voltage to the computer also important due to obtain the right values during the sampling. When the transmission involves a number of components before the data is sent to the computer, it will contribute some delays which will interrupt the right time for the data to be transmitted. To overcome this problem, latching method is applied to the data before it is transmitted in order to hold first the data and avoid the controller from loss it.

6.2 RECOMMENDATION

From this project, the whole circuit of the hardware system must be designed on the PCB in order to reduce the effect of the stray capacitance from the wiring. This way will improve the sensitivity of the circuit with the small changes in the measured capacitance. The prototype of the sensor system can be upgraded by increasing the size of electrodes and reduce the distance between the adjacent electrodes. The screen and projected guards also can be improved by using a harder plastic as to reduce more on the interference of the electromagnetic field from the surrounding. The sampling time for the output signal can be increased by applying higher frequency in the control circuit. The status of the electrodes can be controlled by using the PIC as to increase the effectiveness of the control logic circuit. The control logic circuit can be implemented by using only the PIC via programming the state machine of control logic circuit into the PIC. This will make the data acquisition circuit becomes less complexity.

REFERENCES

1. R A William and M S Back, 1995, *Process Tomography Principles, Techniques, and Applications*, Oxford, Butterworth-Heinemann.
2. Steve Winder , 2003, *Operational Amplifiers*, Newnes.
3. Jacob Fraden, 2004, *Handbook of Modern Sensors Physics, Designs, and Applications*, New York, AIP Press, Springer-Verlag.
4. Edward Hughes, 2002, *Electrical & Electronics Technology*, Italy, Prentice Hall.
5. S.M Huang, C.G Xie, R. Thorn, D. Snowden, and M.S Beck; *Design of Sensor Electronics for Electrical Capacitance Tomography*, *IEE Proc. G*, 1992, 139, (1), pp 83-88.
6. PIC26F87x Data Sheets 28/40-pin 8-Bit CMOS FLASH Microcontrollers, Microchips Technology Inc., 2001
7. Jae Young Lee and Myung Cheol Park; *Development of the Electric Capacitance Tomography for Two-Phase Flow Visualization*, *Proceedings of ICAPP*, (6).
8. www.allaboutcircuits.com
9. www.alldatasheet.com
10. www.futurlec.com
11. www.kpsec.freeuk.com/components

APPENDICES

APPENDIX A

DIELECTRIC MATERIAL AND DIELECTRIC CONSTANT

Examples of dielectric material with its constant

Dielectric material	Dielectric constant, ϵ_r	Dielectric material	Dielectric constant, ϵ_r
Air	1	Air dry (68°F)	1.000536
Water	4-88	Water (32°F)	88
Water (68°F)	80.4	Water (80°F)	80
Water (212°F)	55.3	Water (390°F)	34.5
Water (steam)	1.00785	Mineral oil (80°F)	2.1
Petroleum	2.0-2.2	Heavy oil	3
Gasoline (70°F)	2	LPG	1.6-1.9
Wood (dry)	2-6	Wood (pressed board)	2.0-2.6
Wood (wet)	10-30	Wax	2.4-6.5
Lime	2.2-2.5	Vaseline	2.2-2.9
Thinner	3.7	Teflon (4f)	2.0
Teflon (FEP)	2.1	Teflon (PCTFE)	2.3-2.8
Teflon (PTFE)	2	Polyester resin	2.8-4.5
Paper (dry)	2	Mica	2.6-3.2
Silica (aluminate)	2	Silica (sand)	2.5-3.5
Paint	5-8	Porcelain	5-7
Corn	5-10	Cereals (dry)	3-5
Ash	1.7-2.0	Industrial alcohol	16-31
Cement (plain)	1.5-2.1	Cement (Portland)	2.5-2.6
Cement (powder)	5-10	Chlorine (-50°F)	2.0
Chlorine (32°F)	1.5	Alumina	9.3-11.5

[illegible]

Suggested milestone Process



FYP 2

No.	Detail/ Week	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15
1	Project work continue															
	-Circuit development															
	-Part by part troubleshooting															
2	Submission of Progress Report 1															
3	Project work continue															
	- Circuit development															
	-Part by part troubleshooting															
	-Research and study on imaging															
4	Submission of Progress Report 2															
5	Project work continue															
	-Research and study on imaging															
	-Programming on controller															
	-Programming on Visual Basic 6.0															
6	Submission of Draft Report															
7	Submission of Final Report															
8	Project work continue															
	-Troubleshooting and adjustment															
	-Revision on the current project status															

Suggested milestone

Process

APPENDIX C

TRUTH TABLE AND K MAP FOR CONTROL LOGIC CIRCUIT DESIGN

Condition:

- source electrode = 1
- detecting electrodes = 2, 3, 4, 5, 6, 7, 8

State transition diagram

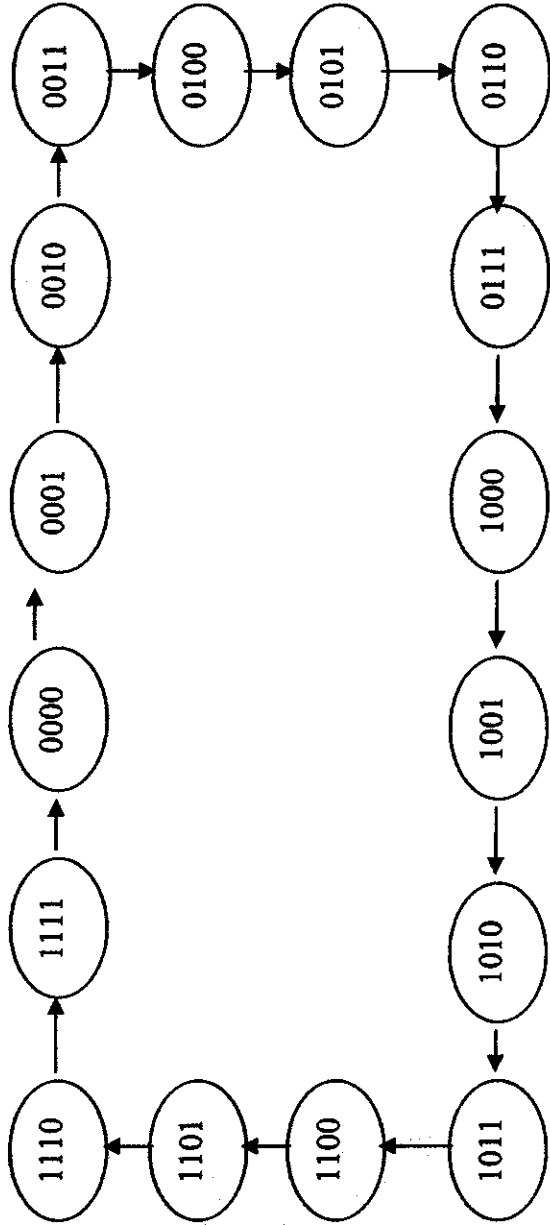


Table C2: Circuit excitation table

PRESENT STATE				NEXT STATE				J _{Q3}	K _{Q3}	J _{Q2}	K _{Q2}	J _{Q1}	K _{Q1}	J _{Q0}	K _{Q0}
Q3	Q2	Q1	Q0	Q3	Q2	Q1	Q0								
0	0	0	0	0	0	0	1	0	X	0	X	0	X	1	X
0	0	0	1	0	0	1	0	0	X	0	X	1	X	X	1
0	0	1	0	0	0	1	1	0	X	0	X	X	0	1	X
0	0	1	1	0	1	0	0	0	X	1	X	X	1	X	1
0	1	0	0	0	1	0	1	0	X	X	0	0	X	1	X
0	1	0	1	0	1	1	0	0	X	X	0	1	X	X	1
0	1	1	0	0	1	1	1	0	X	X	0	X	0	1	X
0	1	1	1	1	0	0	0	1	X	X	1	X	1	X	1
1	0	0	0	1	0	0	1	X	0	0	X	0	X	1	X
1	0	0	1	1	0	1	0	X	0	0	X	1	X	X	1
1	0	1	0	1	0	1	1	X	0	0	X	X	0	1	X
1	0	1	1	1	1	0	0	X	0	1	X	X	1	X	1
1	1	0	0	1	1	0	1	X	0	X	0	0	X	1	X
1	1	0	1	1	1	1	0	X	0	X	0	1	X	X	1
1	1	1	0	1	1	1	1	X	0	X	0	X	0	1	X
1	1	1	1	0	0	0	0	X	1	X	1	X	1	X	1

K maps for control signal of J K flip flops

YZ \ WX	00	01	11	10
	0	0	0	0
00	0	0	0	0
01	0	0	1	0
11	X	X	X	X
10	X	X	X	X

$J_{Q3} = XYZ$

YZ \ WX	00	01	11	10
	X	X	X	X
00	X	X	X	X
01	X	X	X	X
11	0	0	1	0
10	0	0	0	0

$K_{Q3} = XYZ$

YZ \ WX	00	01	11	10
	0	0	1	0
00	0	0	1	0
01	X	X	X	X
11	X	X	X	X
10	0	0	1	0

$J_{Q2} = YZ$

YZ \ WX	00	01	11	10
	X	X	X	X
00	X	X	X	X
01	0	0	1	0
11	0	0	1	0
10	X	X	X	X

$K_{Q2} = YZ$

YZ \ WX	00	01	11	10
	0	1	X	X
00	0	1	X	X
01	0	1	X	X
11	0	1	X	X
10	0	1	X	X

$J_{Q1} = Z$

YZ \ WX	00	01	11	10
	X	X	1	0
00	X	X	1	0
01	X	X	1	0
11	X	X	1	0
10	X	X	1	0

$K_{Q1} = Z$

		YZ	00	01	11	10
WX	00	1	X	X	1	
	01	1	X	X	1	
	11	1	X	X	1	
	10	1	X	X	1	

$J_{Q0} = 1$

		YZ	00	01	11	10
WX	00	X	1	1		X
	01	X	1	1		X
	11	X	1	1		X
	10	X	1	1		X

$K_{Q0} = 1$

K maps for control signal of multiplexer

		YZ	00	01	11	10
WX	00	X	X	1	X	
	01	X	0	1	X	
	11	X	0	1	X	
	10	X	0	1	X	

$A = Y$

		YZ	00	01	11	10
WX	00	X	X	0	X	
	01	X	1	1	X	
	11	X	0	0	X	
	10	X	1	1	X	

$B = \overline{WX} + W\overline{X}$

		YZ	00	01	11	10
WX	00	X	X	0	X	
	01	X	0	0	X	
	11	X	1	1	X	
	10	X	1	1	X	

$C = W$

K maps for control signal of CMOS switches

YZ \ WX	00	01	11	10
00	1	0	0	1
01	1	0	0	1
11	1	0	0	1
10	1	0	0	1

$$S_{1S} = S_{2G} = S_{3G} = S_{4G} = S_{5G} = S_{6G} = S_{7G} = S_{8G} = \bar{Z}$$

YZ \ WX	00	01	11	10
00	0	1	1	0
01	0	1	1	0
11	0	1	1	0
10	0	1	1	0

$$S_{1G} = S_{2M} = S_{3M} = S_{4M} = S_{5M} = S_{6M} = S_{7M} = S_{8M} = Z$$

- $S_{2S} = S_{3S} = S_{4S} = S_{5S} = S_{6S} = S_{7S} = 0$

APPENDIX D
CMOS SWITCHES CD4066B DATA SHEET

CD4068B CMOS QUAD BILATERAL SWITCH

CD4068B-1, NOVEMBER 1988 - REVISED SEPTEMBER 1990

- 16-V Digital Input or 5-V Peak-to-Peak Switching
- 125-Ω Typical On-State Resistance for 15-V Operation
- Frequency Response, Switch On = 40 MHz Typical
- 100-nA Trickle for Quiescent Current at 20 V
- 5-V, 10-V, and 15-V Parametric Ratings
- Meets All Requirements of JEDEC Tentative Standard No. 13-B, Standard Specifications for Description of "B"-Series CMOS Devices
- Applications:
 - Analog signal Switching/Multiplexing: Signal Gating, Modulator, Squarer, Control, Demodulator, Chopper, Commutating Switch
 - Digital signal Switching/Multiplexing
 - Transmission-Gate Logic Implementation
 - Analog-to-Digital and Digital-to-Analog Conversion
 - Digital Control of Frequency, Impedance, Phase, and Analog-signal Gain
- Extremely Low On-State Switch Leakage, Resulting in Very Low Offset Current and High Effective Off-State Resistance: 10 pA Typical at $V_{DD} = V_{SS} = 10\text{ V}$, $T_A = 25^\circ\text{C}$
- Extremely High Control Input Impedance (Control Current Isolated From Signal Circuitry): $10^{12}\Omega$ Typical
- Low Crosstalk Between Switches: -60 dB Typical at $f_{sw} = 5\text{ MHz}$, $R_L = 1\text{ k}\Omega$

E F M NS OR PW PACKAGE
(TOP VIEW)



Description/Ordering Information

The CD4068B is a quad bilateral switch intended for the transmission or multiplexing of analog or digital signals. It is pin-to-pin compatible with the CD4016B, but exhibits a much lower on-state resistance. In addition, the on-state resistance is relatively constant over the full signal-input range.

The CD4068B consists of four bilateral switches, each with independent controls. Both the p and the n devices in a given switch are biased on or off simultaneously by the control signal. As shown in Figure 1, the well of the n-channel device on each switch is tied to either the input (when the switch is on) or to V_{SS} (when the switch is off). This configuration eliminates the variation of the switch-transistor threshold voltage with input signal and, thus, keeps the on-state resistance low over the "full operating-signal range."

The advantages over single-channel switches include peak input-signal voltage swing equal to the full supply voltage and more constant on-state impedance over the input-signal range. However, for sample-and-hold applications, the CD4016B is recommended.

Caution: Be aware that our integrated circuits contain untested, untested, and use in actual applications of Texas Instruments' untested products and devices may result in loss of life and/or property.

CD4068B CMOS QUAD BILATERAL SWITCH

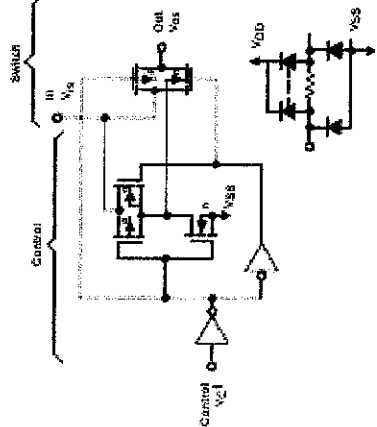
CD4068B-1, NOVEMBER 1988 - REVISED SEPTEMBER 1990

Description/Ordering Information (continued)

ORDERING INFORMATION

TA	PACKAGE*	ORDERABLE PART NUMBER		TOP-SIDE MARKING
		CD4068B-1	CD4068B-1A	
-55°C to 125°C	TO18	CD4068B-1	CD4068B-1A	CD4068B-1A
	TO18	CD4068B-1	CD4068B-1A	CD4068B-1A
	TO18	CD4068B-1	CD4068B-1A	CD4068B-1A
	TO18	CD4068B-1	CD4068B-1A	CD4068B-1A
	TO18	CD4068B-1	CD4068B-1A	CD4068B-1A

* Packages shown are standard leaded packages. New packages are available on request. See the CD4068B-1A data sheet for details.



1. All output signals are produced by the CMOS push-pull network.
NOTES: A. All input signals are referenced to V_{DD} .
B. Minimum operating input signal is $V_{DD}/10$.
C. Signal level range: $V_{SS} \leq V_i \leq V_{DD}$.

Figure 1. Schematic Diagram of One of Four Identical Switches and Associated Control Circuitry

continued

CD4068B
CMOS QUAD BILATERAL SWITCH

201005-2-NOVEMBER 1989 - REVISION 2

absolute maximum ratings over operating free-air temperature (unless otherwise noted):
 DC supply-voltage range, V_{DD} , (voltages referred to V_{SS} terminal) -0.5 V to $+20$ V
 input voltage range, V_{in} , (all inputs) -0.5 V to $V_{DD} + 0.5$ V
 DC input current, I_{in} , (any one input) ± 10 mA
 package thermal impedance, θ_{JA} (see Note 1):
 NS package 62°C/W
 PW package 75°C/W
 FW package 115°C/W

Lead temperature (during soldering) 265°C
 At distance $1/16 \pm 1/32$ inch (1.25 \pm 0.75 mm) from case for 10 s max
 Storage temperature range, T_{STG} -55°C to 125°C

1. Stresses in excess of those listed under "absolute maximum ratings" may cause permanent damage to the device. These are stress ratings only and are not intended to indicate a recommended operating condition. Excessive stress may cause device failure and is not covered by warranty. Excessive stress may cause device failure and is not covered by warranty. Excessive stress may cause device failure and is not covered by warranty.

recommended operating conditions

	MIN	MAX	UNIT
V_{DD} Supply voltage	5	15	V
T_A Operating/free-air temperature	-55	125	$^\circ\text{C}$



POST OFFICE BOX 6555 LUBBOCK TEXAS 79406

CD4068B
CMOS QUAD BILATERAL SWITCH

201005-2-NOVEMBER 1989 - REVISION 2

electrical characteristics

PARAMETER	TEST CONDITIONS	LIMITS AT INDICATED TEMPERATURES						UNIT
		V_{DD} 1V1	V_{DD} 1V1	-50°C	-40°C	25°C	75°C	
DC output current I_{OD}		0.5	5	0.25	0.25	0.25	0.25	μA
		0.10	10	0.5	0.5	0.5	0.5	μA
		0.15	15	1	1	1	1	μA
		0.20	20	5	5	5	5	μA
Signal inputs (V_{in}) and outputs (V_{out})								
On-state resistance r_{ON}	$V_{DD} = V_{DD}$ $V_{in} = 10$ to 15 V $V_{out} = 10$ to 15 V	5	5	500	500	500	500	Ω
	$V_{DD} = V_{DD}$ $V_{in} = 10$ to 15 V $V_{out} = 10$ to 15 V	10	10	500	500	500	500	Ω
	$V_{DD} = V_{DD}$ $V_{in} = 10$ to 15 V $V_{out} = 10$ to 15 V	15	15	500	500	500	500	Ω
	$V_{DD} = V_{DD}$ $V_{in} = 10$ to 15 V $V_{out} = 10$ to 15 V	5	5	500	500	500	500	Ω
On-state resistance of the series switches any two switches $r_{DS(on)}$	$V_{DD} = V_{DD}$ $V_{in} = 10$ to 15 V $V_{out} = 10$ to 15 V	5	5	500	500	500	500	Ω
THD (all inputs at full swing)	$V_{DD} = V_{DD}$ $V_{in} = 10$ to 15 V $V_{out} = 10$ to 15 V	15	15	500	500	500	500	%
-3-dB bandwidth frequency f_{BW}	$V_{DD} = V_{DD}$ $V_{in} = 10$ to 15 V $V_{out} = 10$ to 15 V	5	5	500	500	500	500	MHz
-3-dB bandwidth frequency f_{BW}	$V_{DD} = V_{DD}$ $V_{in} = 10$ to 15 V $V_{out} = 10$ to 15 V	5	5	500	500	500	500	MHz
Input current (with all inputs at full swing) I_{in}	$V_{DD} = V_{DD}$ $V_{in} = 10$ to 15 V $V_{out} = 10$ to 15 V	15	15	500	500	500	500	μA
-3-dB bandwidth frequency f_{BW}	$V_{DD} = V_{DD}$ $V_{in} = 10$ to 15 V $V_{out} = 10$ to 15 V	5	5	500	500	500	500	MHz
Propagation delay input to output t_{pd}	$V_{DD} = V_{DD}$ $V_{in} = 10$ to 15 V $V_{out} = 10$ to 15 V	5	5	500	500	500	500	ns
Capacitance C_{in}	$V_{DD} = V_{DD}$ $V_{in} = 10$ to 15 V $V_{out} = 10$ to 15 V	15	15	500	500	500	500	pF
Capacitance C_{out}	$V_{DD} = V_{DD}$ $V_{in} = 10$ to 15 V $V_{out} = 10$ to 15 V	15	15	500	500	500	500	pF



POST OFFICE BOX 6555 LUBBOCK TEXAS 79406

CD4066B
CMOS QUAD BILATERAL SWITCH

Содержание

TYPICAL CHARACTERISTICS

Figure 3 is a graph showing the typical on-state resistance versus input signal voltage for the 2N5000 tube. The y-axis represents Output Current - I_o in mA, ranging from 0 to 300. The x-axis represents Input Signal Voltage - V_i in V, ranging from -10 to 10. Three curves are plotted for different temperatures: 125°C, 25°C, and -55°C. The curves show a peak in current around 0V and a dip around ±2.5V. The current increases with temperature.

2014年12月15日

Figure 1 consists of two graphs, A and B, showing the effect of temperature on the rate of polymerization. Both graphs plot the rate of polymerization (R_p) on the y-axis against temperature (T) in degrees Celsius on the x-axis. The x-axis ranges from 0 to 150°C with major ticks every 10 units. The y-axis ranges from 0 to 0.001 with major ticks every 0.0002 units. Graph A shows a curve that starts at approximately (20, 0.0001), rises to a peak of about 0.0004 at 100°C, and then decreases to about 0.0002 at 150°C. Graph B shows a similar curve, starting at approximately (20, 0.0001), rising to a peak of about 0.0004 at 100°C, and then decreasing to about 0.0002 at 150°C. Both graphs include a legend indicating that the solid line represents the rate of polymerization (R_p) and the dashed line represents the rate of polymerization (R_p).

CD4068B CMOS QUAD BILATERAL SWITCH

20150101-10:00:00 - 2015 - REVISED (REVISED 2015)

TYPICAL CHARACTERISTICS

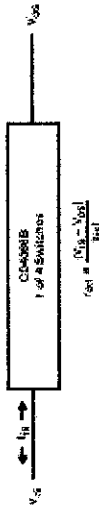


Figure 6. Determination of I_{on} as a Test Condition for Control-Input High-Voltage (V_{IHC}) Specification

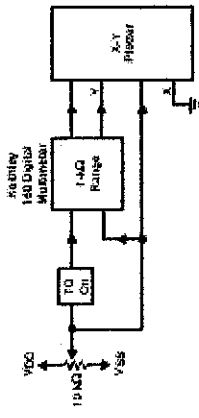


Figure 7. Channel On-State Resistance Measurement Circuit

POWER DISSIPATION PER PACKAGE VS SWITCHING FREQUENCY

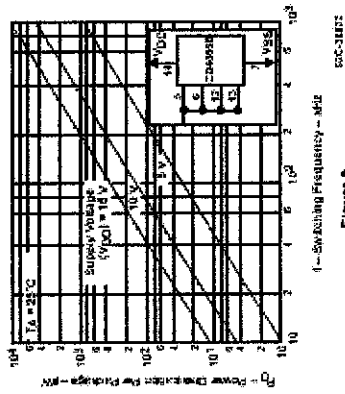


Figure 8

Figure 9

1 - Switching Frequency - MHz

2015-2015

2015-2015

V_I - Input Voltage - V

Figure 6

CD4068B CMOS QUAD BILATERAL SWITCH

20150101-10:00:00 - 2015 - REVISED (REVISED 2015)

TYPICAL CHARACTERISTICS

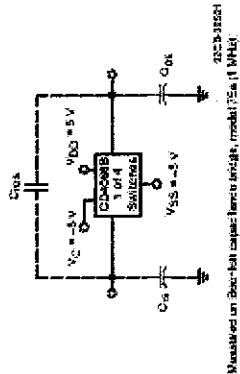


Figure 10. Typical On Characteristics for One of Four Channels

Figure 11. Off-Switch Input or Output Leakage

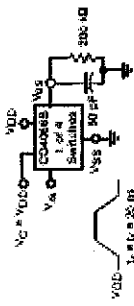


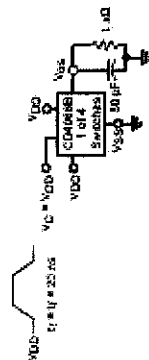
Figure 12. Propagation Delay Time Signal Input (V_I) to Signal Output (V_O)

Figure 13. Crosstalk-Control Input to Signal Output

CD-4066B
CMOS QUAD BILATERAL SWITCH

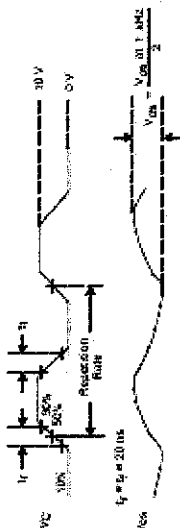
THE UNIVERSITY OF CHICAGO PRESS

TYPICAL CHARACTERISTICS



התאחדות

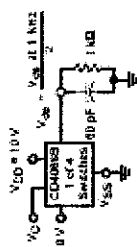
Figure 14. Propagation Delay, t_{pd} , vs. Load Control-Signal Output

Figure 14. Propagation Delay, t_{pd} , Low Control-Signal Output

PC 5-13925

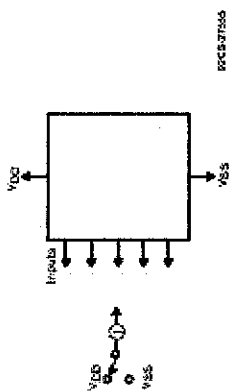
Figure 15. Maximum Allowable Control-Input Repetition Rate

Figure 15. Maximum Allowable Control-Input Repetition Rate

CD4066B
CMOS QUAD BILATERAL SWITCH

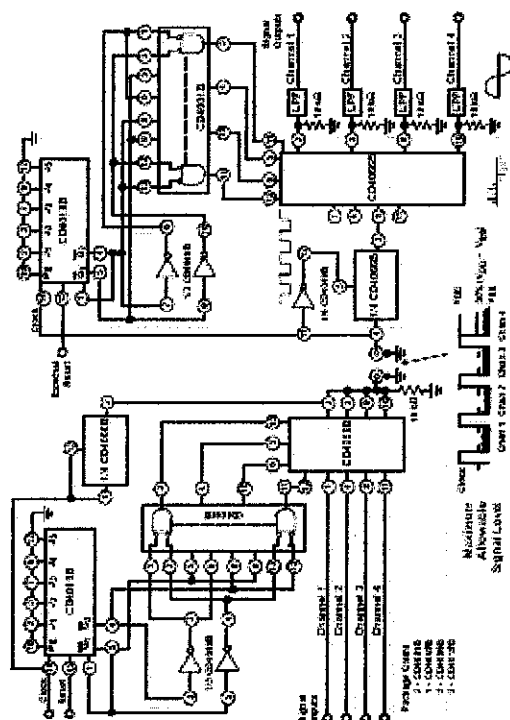
Source: U.S. Department of Commerce - Bureau of Economic Analysis

TYPICAL CHARACTERISTICS



addition, the *Journal of the American Statistical Association* has published a special issue on "The Role of Statistics in the Social Sciences" (Volume 100, Number 4, December 2005).

Figure 16. Input Leakage-Current Test Circuit



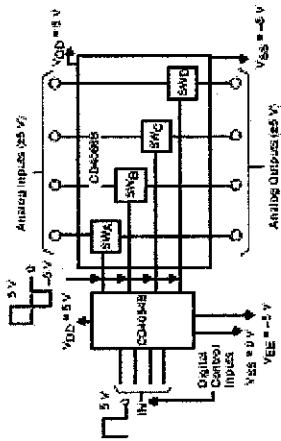
—

Figure 17. Four-Chambered Fish Culture System (Chang et al., 2007)

CD4068B
CMOS QUAD BILATERAL SWITCH

SCHEMATIC SYMBOLS ARE SHOWN FOR THE CD4068B

TYPICAL CHARACTERISTICS



20C3-31137

Figure 18. Bidirectional Signal Transmission via Digital Control Logic

APPENDIX E
OPERATIONAL AMPLIFIER LF353 DATA SHEET

LF353 Wide Bandwidth Dual JFET Input Operational Amplifier

August 2005

National Semiconductor

LF353 Wide Bandwidth Dual JFET Input Operational Amplifier

General Description

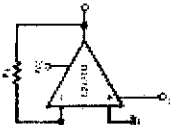
These devices are low cost, high speed, dual JFET input operational amplifiers with an internally trimmed input offset voltage (in-FET) architecture. They require low supply current yet maintain a high gain bandwidth product that makes them suitable for low input bias and offset currents. The LF353 is also compatible with the standard LM259 of active designs to form a fully compatible dual JFET input operational amplifier.

These amplifiers may be used in applications such as: high speed comparators, fast data converters, sample and hold circuits, and many other circuits requiring low input offset voltage, low input bias current, high input impedance, high slew rate and wide bandwidth. The devices also exhibit low noise and offset voltage drift.

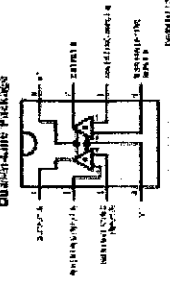
Features

- Internally trimmed offset voltage
- Low input bias current
- Low input noise voltage
- Low input noise current
- Wide gain bandwidth
- High slew rate
- Low supply current
- High input impedance
- Low total harmonic distortion
- Low 1/f noise corner
- Fast settling time to 0.1%

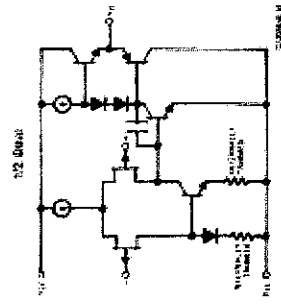
Typical Connection



Connection Diagram



Simplified Schematic



Order Number LF353N, LF353M, or LF353JN
See NS Package Number M86A or N86B

19527

Absolute Maximum Ratings (Note 1)
If Military/Space specified devices are required, consult the National Semiconductor Sales Office for availability and specifications.

Supply Voltage $\pm 15V$
Power Dissipation (Note 2)
Operating Temperature Range $-55^{\circ}C$ to $+125^{\circ}C$
TA(MAX)
Differential Input Voltage $\pm 30V$
Input Voltage Range (Note 3)
Output Short-Circuit Current $\pm 15V$
Storage Temperature Range $-65^{\circ}C$ to $+150^{\circ}C$
Lead Temp. (Soldering, 10 sec.) $260^{\circ}C$
Soldering Temperature (Wave Soldering, 10 sec.) $350^{\circ}C$

DC Electrical Characteristics
(Note 4)

Symbol	Parameter	Conditions	LF353	Units
V_{in}	Input Offset Voltage	$R_L = 1M\Omega$, $T_A = 25^{\circ}C$ Over Temperature	5	mV
A_{VCL}	Average TC of Input Offset Voltage	$R_L = 10k\Omega$ $T_A = 25^{\circ}C$ (Notes 5, 6)	10	$\mu V/C$
I_{in}	Input Bias Current	$T_A = 25^{\circ}C$ (Notes 5, 6)	50	pA
R_{in}	Input Resistance	$T_A = 25^{\circ}C$	1.5	G Ω
A_{vcl}	Large Signal Voltage Gain	$V_{in} = 15V$, $T_A = 25^{\circ}C$ $V_{out} = 10V$, $R_L = 2k\Omega$	25	V/V
V_{ic}	Offset Voltage Swing	Over Temperature	15	mV
V_{cm}	Input Common-Mode Voltage Range	$V_{in} = 15V$, $R_L = 10k\Omega$ $V_{out} = 15V$	± 12 ± 15	V
C_{MRR}	Common-Mode Rejection Ratio	$R_L = 10k\Omega$	70	dB
$PSRR$	Supply Voltage Rejection Ratio	Notes 7, 8	70	dB
I_q	Supply Current		8.5	mA

AC Electrical Characteristics

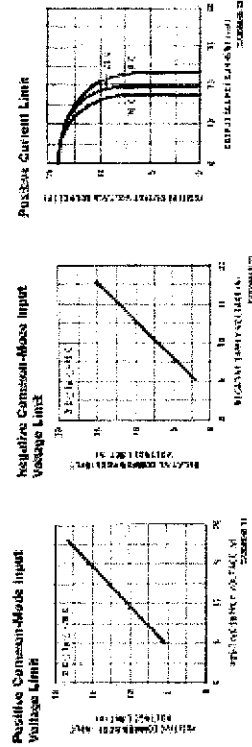
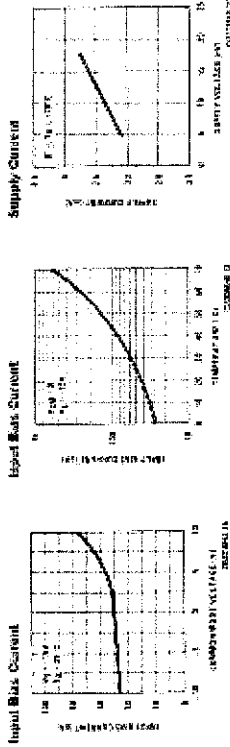
Symbol	Parameter	Conditions	LF353	Units
	Amplifier to Amplifier Coupling	$T_A = 25^{\circ}C$, $f = 1$ Hz to 20 MHz (Input Referenced)	≥ 20	dB
SR	Slew Rate	$V_{in} = 15V$, $T_A = 25^{\circ}C$	6.0	V/ μs
GBW	Gain Bandwidth Product	$V_{in} = 15V$, $T_A = 25^{\circ}C$	2.7	MHz
f_u	Equivalent Input Noise Voltage	$T_A = 25^{\circ}C$, $R_N = 10k\Omega$ $f = 100$ Hz	15	nV/ \sqrt{Hz}
i_n	Equivalent Input Noise Current	$T_A = 25^{\circ}C$, $R_N = 10k\Omega$	0.51	pA/ \sqrt{Hz}

AC Electrical Characteristics (Continued)

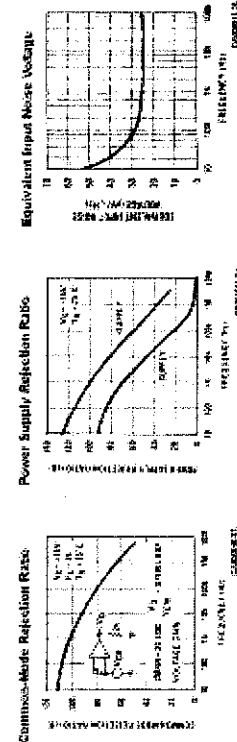
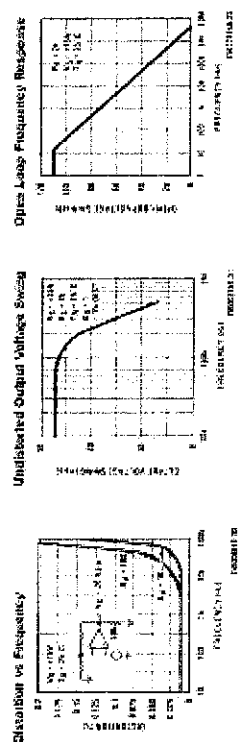
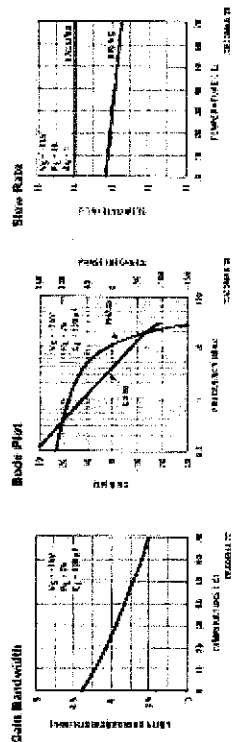
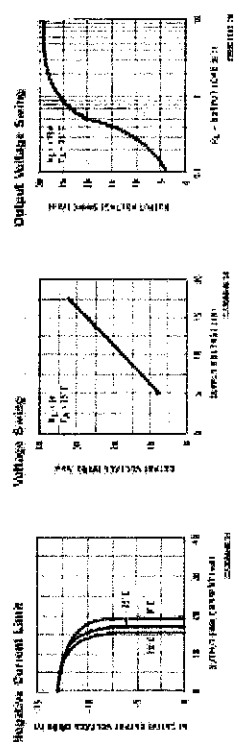
Symbol	Parameter	Conditions	LF358			Units
			Min	Typ	Max	
T_{HD}	Total Harmonic Distortion	$R_L = 10k\Omega$, $R_{in} = 10k\Omega$, $V_{in} = 250mV$, $f = 1kHz$, $SR = 20V/\mu s$, $V_{CC} = 15V$		<0.02		%

- Note 1: Frequency at maximum distortion is 100kHz. The maximum distortion is limited by the input signal level and the load impedance. The maximum distortion is limited by the input signal level and the load impedance.
- Note 2: The power dissipation is limited by the ambient temperature and the power dissipation rating of the package. The power dissipation is limited by the ambient temperature and the power dissipation rating of the package.
- Note 3: The power dissipation is limited by the ambient temperature and the power dissipation rating of the package. The power dissipation is limited by the ambient temperature and the power dissipation rating of the package.
- Note 4: The power dissipation is limited by the ambient temperature and the power dissipation rating of the package. The power dissipation is limited by the ambient temperature and the power dissipation rating of the package.
- Note 5: The power dissipation is limited by the ambient temperature and the power dissipation rating of the package. The power dissipation is limited by the ambient temperature and the power dissipation rating of the package.
- Note 6: The power dissipation is limited by the ambient temperature and the power dissipation rating of the package. The power dissipation is limited by the ambient temperature and the power dissipation rating of the package.
- Note 7: The power dissipation is limited by the ambient temperature and the power dissipation rating of the package. The power dissipation is limited by the ambient temperature and the power dissipation rating of the package.
- Note 8: The power dissipation is limited by the ambient temperature and the power dissipation rating of the package. The power dissipation is limited by the ambient temperature and the power dissipation rating of the package.
- Note 9: The power dissipation is limited by the ambient temperature and the power dissipation rating of the package. The power dissipation is limited by the ambient temperature and the power dissipation rating of the package.
- Note 10: The power dissipation is limited by the ambient temperature and the power dissipation rating of the package. The power dissipation is limited by the ambient temperature and the power dissipation rating of the package.

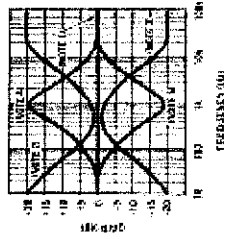
Typical Performance Characteristics



Typical Performance Characteristics (Continued)

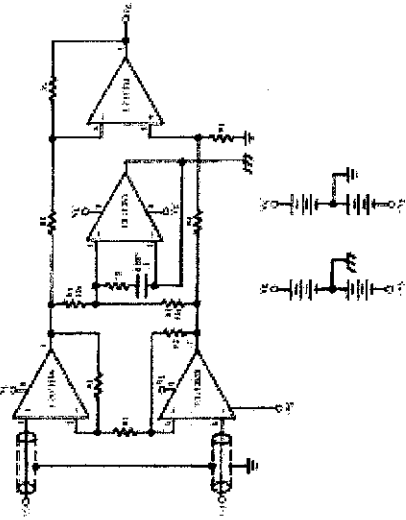


Typical Applications (Continued)



- Notes: 1. All resistors are 1% tolerance.
- 2. Bias and mode select, w/ 4.7k.
- 3. Bias and mode select, w/ 4.7k.
- 4. Bias and mode select, w/ 4.7k.
- 5. Bias and mode select, w/ 4.7k.
- 6. Bias and mode select, w/ 4.7k.
- 7. Bias and mode select, w/ 4.7k.
- 8. Bias and mode select, w/ 4.7k.
- 9. Bias and mode select, w/ 4.7k.
- 10. Bias and mode select, w/ 4.7k.

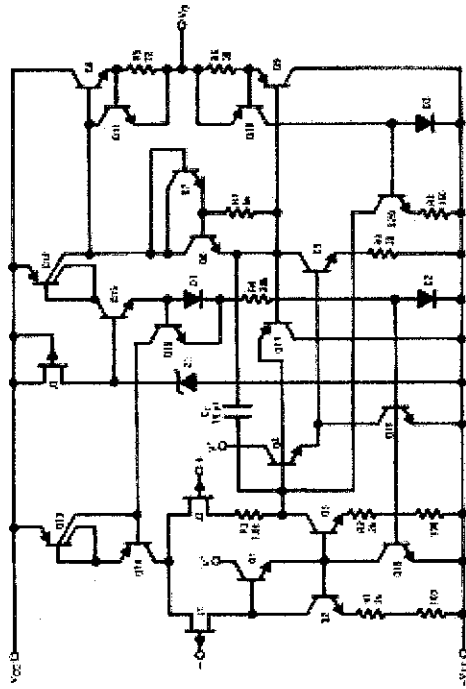
Improved CMRR Instrumentation Amplifier



$$A_{CM} = \left(\frac{R_{12}}{R_{11}} \right) \left(\frac{R_{13}}{R_{14}} \right)$$

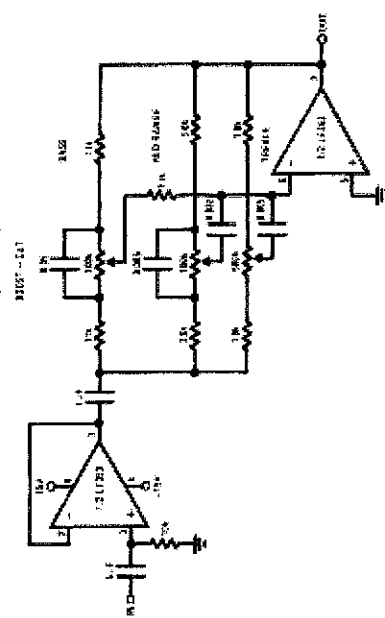
- Notes: 1. All resistors are 1% tolerance.
- 2. Bias and mode select, w/ 4.7k.
- 3. Bias and mode select, w/ 4.7k.
- 4. Bias and mode select, w/ 4.7k.
- 5. Bias and mode select, w/ 4.7k.
- 6. Bias and mode select, w/ 4.7k.
- 7. Bias and mode select, w/ 4.7k.
- 8. Bias and mode select, w/ 4.7k.
- 9. Bias and mode select, w/ 4.7k.
- 10. Bias and mode select, w/ 4.7k.

Detailed Schematic



Typical Applications

Three-Stage Active Voice Conditioner



APPENDIX F
MULTIPLEXER CD4051 DATA SHEET

CD4051B, CD4052B, CD4053B

DATE OF DEATH: 1961, JANUARY

CMOS Analog Multiplexers/Demultiplexers with Logic Level Conversion

[illegible]

These conditions are subject to change. The Department may vary the
policy by committee, A. B. C. D. E. F. G. H. I. J. K. L. M. N. O. P. Q. R. S. T. U. V. W. X. Y. Z. AA. AB. AC. AD. AE. AF. AG. AH. AI. AJ. AK. AL. AM. AN. AO. AP. AQ. AR. AS. AT. AU. AV. AW. AX. AY. AZ. BA. BB. BC. BD. BE. BF. BG. BH. BI. BJ. BK. BL. BM. BN. BO. BP. BQ. BR. BS. BT. BU. BV. BW. BX. BY. BZ. CA. CB. CC. CD. CE. CF. CG. CH. CI. CJ. CK. CL. CM. CN. CO. CP. CQ. CR. CS. CT. CU. CV. CW. CX. CY. CZ. DA. DB. DC. DD. DE. DF. DG. DH. DI. DJ. DK. DL. DM. DN. DO. DP. DQ. DR. DS. DT. DU. DV. DW. DX. DY. DZ. EA. EB. EC. ED. EE. EF. EG. EH. EI. EJ. EK. EL. EM. EN. EO. EP. EQ. ER. ES. ET. EU. EV. EW. EX. EY. EZ. FA. FB. FC. FD. FE. FF. FG. FH. FI. FJ. FK. FL. FM. FN. FO. FP. FQ. FR. FS. FT. FU. FV. FW. FX. FY. FZ. GA. GB. GC. GD. GE. GF. GG. GH. GI. GJ. GK. GL. GM. GN. GO. GP. GQ. GR. GS. GT. GU. GV. GW. GX. GY. GZ. HA. HB. HC. HD. HE. HF. HG. HH. HI. HJ. HK. HL. HM. HN. HO. HP. HQ. HR. HS. HT. HU. HV. HW. HX. HY. HZ. IA. IB. IC. ID. IE. IF. IG. IH. II. IJ. IK. IL. IM. IN. IO. IP. IQ. IR. IS. IT. IU. IV. IW. IX. IY. IZ. JA. JB. JC. JD. JE. JF. JG. JH. JI. JJ. JK. JL. JM. JN. JO. JP. JQ. JR. JS. JT. JU. JV. JW. JX. JY. JZ. KA. KB. KC. KD. KE. KF. KG. KH. KI. KJ. KK. KL. KM. KN. KO. KP. KQ. KR. KS. KT. KU. KV. KW. KX. KY. KZ. LA. LB. LC. LD. LE. LF. LG. LH. LI. LJ. LK. LL. LM. LN. LO. LP. LQ. LR. LS. LT. LU. LV. LW. LX. LY. LZ. MA. MB. MC. MD. ME. MF. MG. MH. MI. MJ. MK. ML. MM. MN. MO. MP. MQ. MR. MS. MT. MU. MV. MW. MX. MY. MZ. NA. NB. NC. ND. NE. NF. NG. NH. NI. NJ. NK. NL. NM. NO. NP. NQ. NR. NS. NT. NU. NV. NW. NX. NY. NZ. OA. OB. OC. OD. OE. OF. OG. OH. OI. OJ. OK. OL. OM. ON. OO. OP. OQ. OR. OS. OT. OU. OV. OW. OX. OY. OZ. PA. PB. PC. PD. PE. PF. PG. PH. PI. PJ. PK. PL. PM. PN. PO. PP. PQ. PR. PS. PT. PU. PV. PW. PX. PY. PZ. QA. QB. QC. QD. QE. QF. QG. QH. QI. QJ. QK. QL. QM. QN. QO. QP. QQ. QR. QS. QT. QU. QV. QW. QX. QY. QZ. RA. RB. RC. RD. RE. RF. RG. RH. RI. RJ. RK. RL. RM. RN. RO. RP. RQ. RR. RS. RT. RU. RV. RW. RX. RY. RZ. SA. SB. SC. SD. SE. SF. SG. SH. SI. SJ. SK. SL. SM. SN. SO. SP. SQ. SR. SS. ST. SU. SV. SW. SX. SY. SZ. TA. TB. TC. TD. TE. TF. TG. TH. TI. TJ. TK. TL. TM. TN. TO. TP. TQ. TR. TS. TT. TU. TV. TW. TX. TY. TZ. UA. UB. UC. UD. UE. UF. UG. UH. UI. UJ. UK. UL. UM. UN. UO. UP. UQ. UR. US. UT. UU. UV. UW. UX. UY. UZ. VA. VB. VC. VD. VE. VF. VG. VH. VI. VJ. VK. VL. VM. VN. VO. VP. VQ. VR. VS. VT. VU. VV. VW. VX. VY. VZ. WA. WB. WC. WD. WE. WF. WG. WH. WI. WJ. WK. WL. WM. WN. WO. WP. WQ. WR. WS. WT. WU. WV. WW. WX. WY. WZ. XA. XB. XC. XD. XE. XF. XG. XH. XI. XJ. XK. XL. XM. XN. XO. XP. XQ. XR. XS. XT. XU. XV. XW. XX. XY. XZ. YA. YB. YC. YD. YE. YF. YG. YH. YI. YJ. YK. YL. YM. YN. YO. YP. YQ. YR. YS. YT. YU. YV. YW. YX. YY. YZ. ZA. ZB. ZC. ZD. ZE. ZF. ZG. ZH. ZI. ZJ. ZK. ZL. ZM. ZN. ZO. ZP. ZQ. ZR. ZS. ZT. ZU. ZV. ZW. ZX. ZY. ZZ.

1. **செயல்பாடு:** இது ஒரு கட்டிடப் பணியாகும். இது ஒரு கட்டிடப் பணியாகும். இது ஒரு கட்டிடப் பணியாகும்.

[illegible]

When these services are used at different intervals, the data are called "noncontingent" and are the subject of the second chapter.

Ordering information

PART NUMBER	TEMP. RANGE (°C)	PACKAGE
COM451BF, COM452BF, COM453BF	-55 to 125	1914 CERAMIC DIP
COM451BE, COM452BE, COM453BE	-55 to 125	1914C PDIP
COM451BM, COM452BM	-55 to 125	1914L SOTC
COM451BTH, COM452BTH, COM453BTH	-55 to 125	1914L TSSOP

[illegible]

Subject

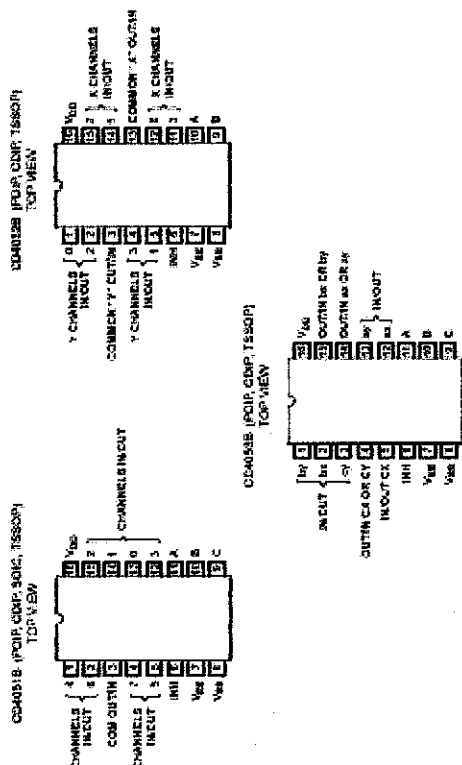
- Wide Range of Digital and Analog Signal Levels
- Digital: 0V to 5V
 - Analog: 0V to 2.5V
- Low On-Resistance - 250 Ω /Pin Over Full Input Range for $V_{DD} = 5V$
- High Off-Resistance: Channels Leakage of ≤ 100 pA/ V_{DD} at $V_{DD} = 5V$
- Low Input Currents for 5V Input Acrossing Supplies of 3V to 20V, $I_{DD} = 5V$ to 20V to Sink/Source
- Switches to 20V V_{DD} $V_{EE} = 20V$
- Matched Switch Characteristic: Ion = 800 pA/ V_{DD} for $V_{DD} = 5V$
- Very Low Quiescent Power: Dissipated Under All Circuit Configurations and Supply Conditions, $I_{DD} = 100$ nA
- $V_{DD} = 5V$, $V_{EE} = 0V$ $V_{EE} = 14V$
- 3-Bit Address Decoding or 8-to-1
- 5V, 10V and 14V Parameter Ratings
- 120V Means for Quiescent Current at 20V
- Maximum Input Current of 100 nA at 10V Full Package
- Temperature Range: -40°C to +125°C
- 8-Wire 20-Pin Widebus™ Packaging Eliminates External Connectors

Applications

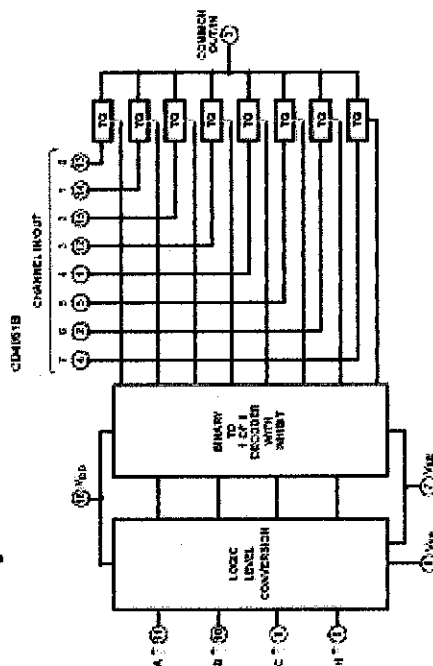
- Applied and Digital Marketing and Communications
AD and DVA Conversion
Social Gaming

Pinouts

CD4051B, CD4052B, CD4053B

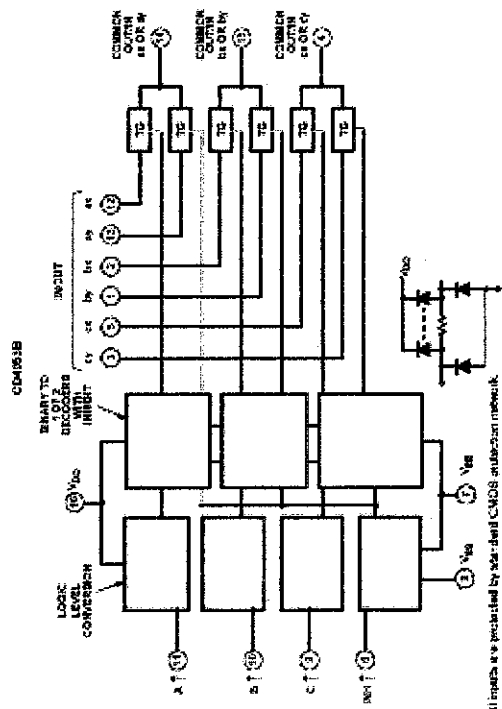
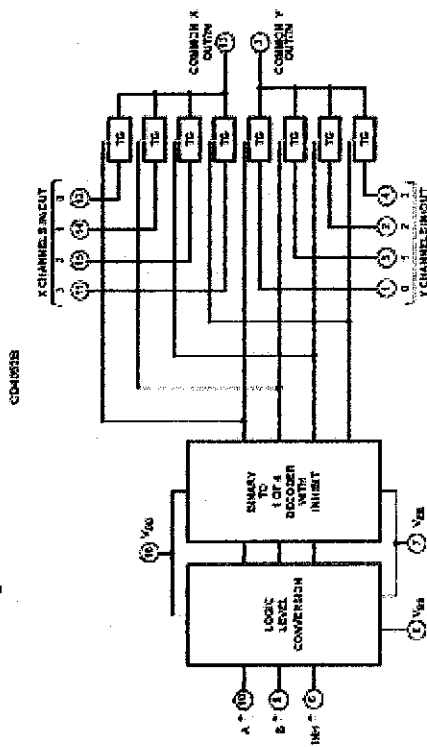


Functional Block Diagrams



STUDYING THE SCIENCE OF LANGUAGE

Functional Block Diagrams (Continued)



TRUTH TABLES

INPUT STATES				10N-CHANNEL(S)
INHIBIT	C	B	A	
CD4051B				
0	0	0	0	0
0	0	0	1	1
0	0	1	0	2
0	0	1	1	3
0	1	0	0	4
0	1	0	1	5
0	1	1	0	6
0	1	1	1	7
1	X	X	X	None
CD4052B				
INHIBIT				
0	0	0	0	0x, 0y
0	0	0	1	1x, 1y
0	0	1	0	2x, 2y
0	0	1	1	3x, 3y
1	X	X	X	None
CD4053B				
INHIBIT				
0	0	0	0	0x, 0y, 0z
0	0	1	1	1x, 1y, 1z
1	X	X	X	None
CD4054B				
INHIBIT				
0	0	0	0	0x, 0y, 0z
0	0	1	1	1x, 1y, 1z
1	X	X	X	None

X = Don't Care

CD4051B, CD4052B, CD4053B

[illegible]

© 2004 Blackwell Publishing Ltd *Journal of Internal Medicine* 255: 103–112

For a more detailed description of the

Electrical Voltage Recorder

CC (reg.) 100-100000 Army Ord.

Outcomes in Adolescent Patients

ଓପେନିଂ କମିଶନ

Theory

11578311 NSTL 0711140731
Theoretical Quantum Mechanics

Electrical Specifications

PARAMETER	TEST CONDITIONS				LIMITS	
	V_{IN} (V)	V_{DD} (V)	R_L (M Ω)		TYP	UNITS
Total Harmonic Distortion, THD	2 (Noise 3)	5	10		3.5	%
	5 (Noise 3)	10			3.2	%
	5 (Noise 3)	15			0.12	%
	$V_{IN} = V_{DD}/2$, $f_{sig} = 100$ kHz, $V_{DD} = 10$ V					
ACB Feedthrough Frequency (All Channels Off)	5 (Noise 3)	10		V_{DD} at Channel OUT1N	6	MHz
				$V_{DD} = V_{DD}/2$	10	MHz
				$V_{DD} = V_{DD}/2$	12	MHz
ACB Signal Circulator Frequency	5 (Noise 3)	10		V_{DD} at Any Channel	6	MHz
				Between Any 2 Channels	2	MHz
				Measured in Current, COM2ES Only	6	MHz
Between Any Two Sections, COM2ES Only	5 (Noise 3)	10		Measured in Any Channel	10	MHz
				Between Any Two Sections, COM2ES Only	2.5	MHz
				Between 15, 14, 13, 12, 11, 10, 9, 8, 7, 6, 5, 4, 3, 2, 1	6	MHz
Adaptive-switch Time-Signal Circuit C					65	nV/Hz/Hz
					65	nV/Hz/Hz

NOTES

- 1. Peak-to-peak voltage symmetrical about $V_{DD} - V_{TH}$
- 2. Between 2 channels

Typical Performance Curves

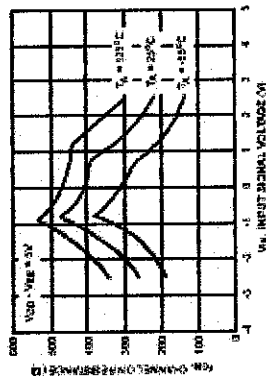


FIGURE 1. CHANNEL ON RESISTANCE VS INPUT SIGNAL VOLTAGE (ALL TYPES)

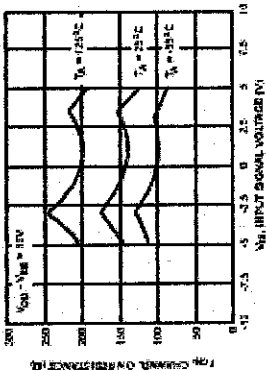
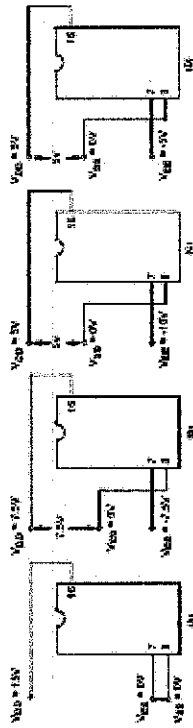


FIGURE 2. CHANNEL ON RESISTANCE VS INPUT SIGNAL VOLTAGE (ALL TYPES)

Test Circuits and Waveforms



NOTE: This ADDRESS (ADDRESS) and (INHIBIT) signals are: "0" = V_{DD} and "1" = V_{SS} . The analog signal (through the I/O) may swing from V_{SS} to V_{DD} .

FIGURE 3. TYPICAL BIAS VOLTAGES

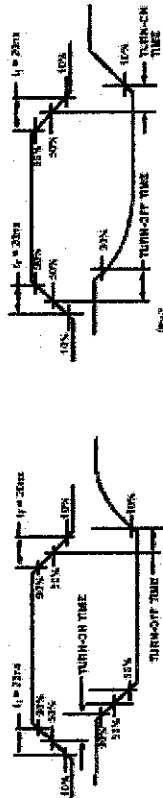


FIGURE 10. WAVEFORMS, CHANNEL BEING TURNED ON ($R_L = 10k\Omega$)

FIGURE 11. WAVEFORMS, CHANNEL BEING TURNED OFF ($R_L = 10k\Omega$)

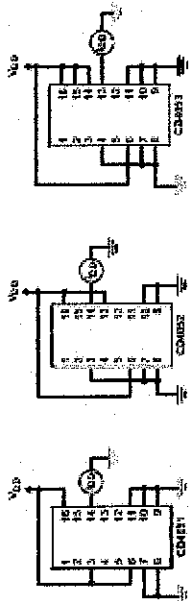


FIGURE 12. OFF CHANNEL LEAKAGE CURRENT - ANY CHANNEL OFF

APPENDIX G
PIC16F877 (ADC CONVERSION)

APPENDIX H
MAX232 DATA SHEET

14

++5V-Powered, Multichannel RS-232 Drivers/Receivers

MAX220-MAX249

ELECTRICAL CHARACTERISTICS...MAX223/MAX280-MAX241 (continued)

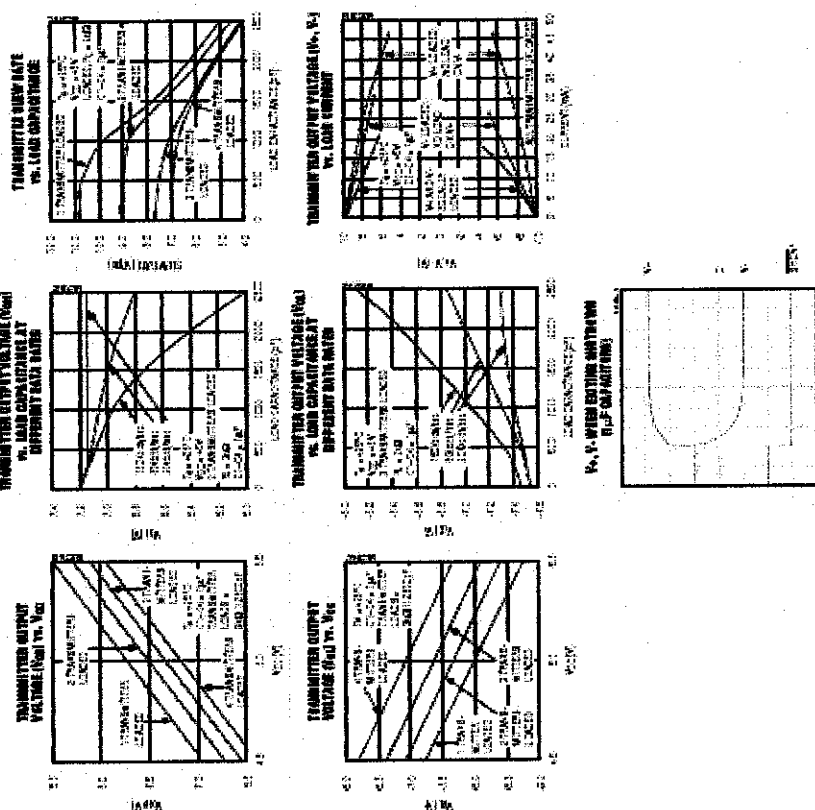
PARAMETER	CONDITIONS		MIN	TYP	MAX	UNITS
	TA = +25°C, VCC = 5V	Normal operation SPCH = 5V (MAX232), SPCH = CV (MAX232/232C04), Shutdown (MAX232), SPCH = CV, SPCH = 5V (94A, 94B)				
PS-332 Input Threshold Low			0.8	1.2		V
PS-332 Input Threshold High			0.8	1.5		V
PS-332 Input Threshold High	TA = +25°C, VCC = 5V	Normal operation SPCH = 5V (MAX232), SPCH = CV (MAX232/232C04), Shutdown (MAX232), SPCH = CV, EN = 5V (94A, 94B)	1.7	2.4		V
PS-332 Input Hysteresis			0.2	0.8	1.0	V
PS-332 Input Resistance	TA = +25°C, VCC = 5V	EN = 25V, VCC = 5V	3	5	7	kΩ
TTLCMOS Output Voltage Low		EN = 25V, VCC = 5V, IOUT = 1.0mA		0.4		V
TTLCMOS Output Voltage High		EN = 25V, VCC = 5V, IOUT = 1.0mA		3.5	VCC - 0.4	V
TTLCMOS Output Leakage Current		CMOS Input: VCC, EN = CV, MAX232; EN = VCC, MAX232 - 2411		0.05	±10	μA
Receiver Output Enable Time	Normal operation	MAX232		600		ns
Receiver Output Disable Time	Normal operation	MAX232/232C04/232C04A		400		ns
Propagation Delay	PS-332 N/A TTLCMOS OUT CV = 150pF	MAX232 MAX232/232C04/232C04A		500		ns
		Normal operation		250		ns
	PS-332 N/A TTLCMOS OUT CV = 150pF	Normal operation		0.5	1.0	ns
		SPCH = 5V (MAX232)		4	40	μs
				6	40	μs
Transition Region Slew Rate	MAX232/MAX232A/MAX232-241: TA = +25°C, VCC = 5V, RA = 30k to 10k, CV = 25pF to 500pF, measured from +3V to -3V or -3V to +3V	MAX232/MAX232A/MAX232-241: TA = +25°C, VCC = 5V, RA = 30k to 10k, CV = 25pF to 500pF, measured from +3V to -3V or -3V to +3V	3	3.1	50	V/μs
Transmitter Output Resistance		MAX232/MAX232A/MAX232-241: TA = +25°C, VCC = 5V, RA = 30k to 10k, CV = 25pF to 500pF, measured from +3V to -3V or -3V to +3V		4	50	Ω
Transmitter Output Resistance		VCC = VCC, EN = CV, ENAT = +3V	920			Ω
Transmitter Output Short-Circuit Current				±10		mA

+5V-Powered, Multichannel RS-232 Drivers/Receivers

MAX220-MAX249

Typical Operating Characteristics

1-800-441-DECKA-441823791



MAX220-MAX249 +5V-Powered, Multichannel RS-232 Drivers/Receivers

Tables 1a-1d define the control states. The MAX234 has no control pins and is not included in these tables. The MAX235 has ten receivers and eight drivers with two control pins, each controlling one side of the device. A logic high at the A-side control pin (ENA) causes the four A-side receivers and drivers to go into a three-state mode. Similarly, the B-side control pin (ENB) causes the four B-side drivers and receivers to go into a three-state mode. As in the MAX235, one A-side and one B-side receiver (R05 and R06) remain active at all times. The entire device is put into shutdown mode when both the A- and B-sides are disabled (ENA = ENB = +5V).

The MAX247 provides nine receivers and eight drivers with four control pins. The ENRX and ENRB receiver enable inputs each control four receiver outputs. The ENTX and ENTB transmitter enable inputs each control four drivers. The ninth receiver (R05) is always active. The device enters shutdown mode with a logic high on both ENTX and ENTB.

The MAX248 provides eight receivers and eight drivers with four control pins. The ENRX and ENRB receiver enable inputs each control four receiver outputs. The ENTX and ENTB transmitter enable inputs control four drivers each. This part does not have an always-active receiver. The device enters shutdown mode and transmitters go into a three-state mode with a logic high on both ENTX and ENTB.

The MAX249 provides ten receivers and six drivers with four control pins. The ENRX and ENRB receiver enable inputs each control five receiver outputs. The ENTX and ENTB transmitter enable inputs control three drivers each. There is no always-active receiver. The device enters shutdown mode and transmitters go into a three-state mode with a logic high on both ENTX and ENTB. In shutdown mode, active receivers operate in a low-power receive mode at data rates up to 230kbaud.

Applications Information

Figures 5 through 8 show pin configurations and typical operating circuits. In applications that are sensitive to power-supply noise, VCC should be decoupled to ground with a capacitor of the same value as C1 and C2 connected as close as possible to the device.

MAX220-MAX249

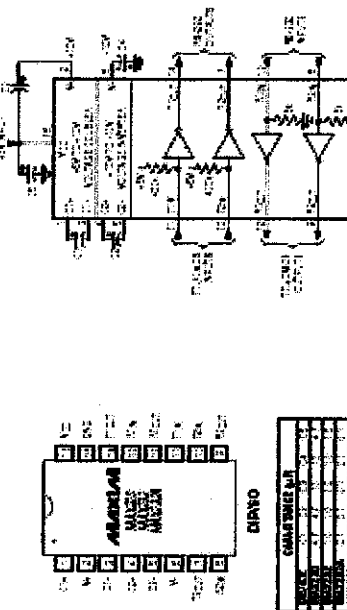


Figure 5. MAX220/MAX235/MAX234 Pin Configuration and Typical Operating Circuit

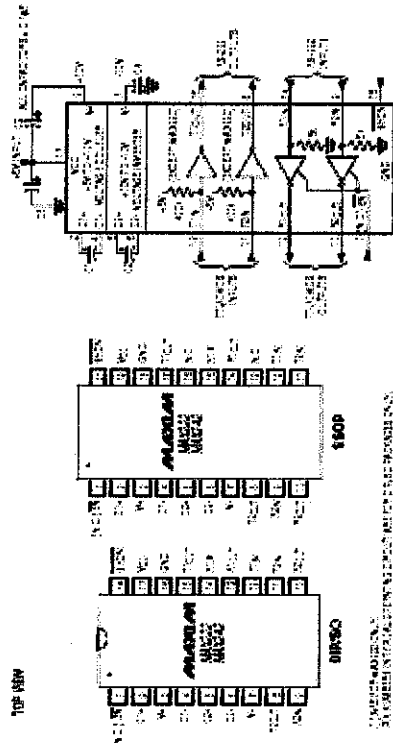


Figure 6. MAX220/MAX248 Pin Configuration and Typical Operating Circuit